

Strangeness in Quark Matter 2024 Strasbourg, France



The ITS3 detector and physics reach of the LS3 ALICE Upgrade

Chunzheng Wang* (for the ALICE Collaboration)

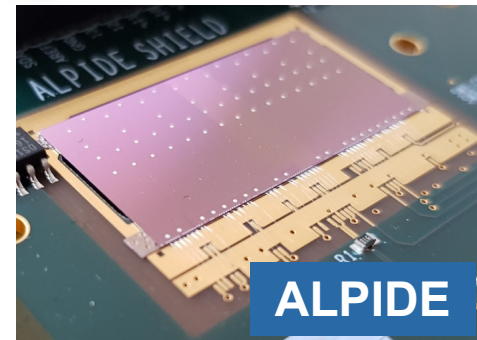
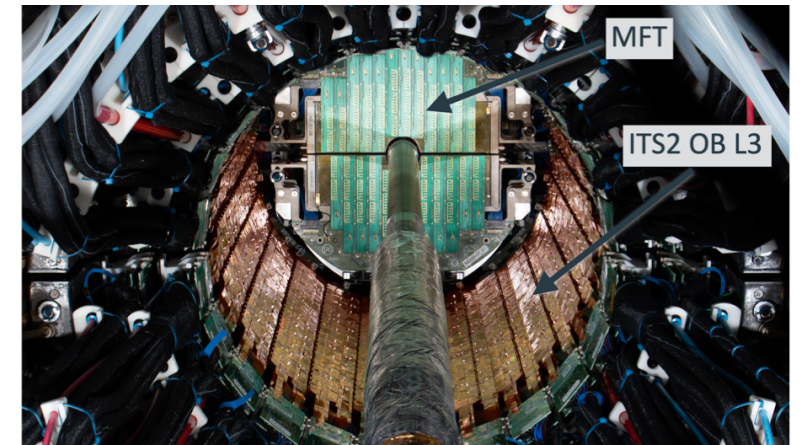
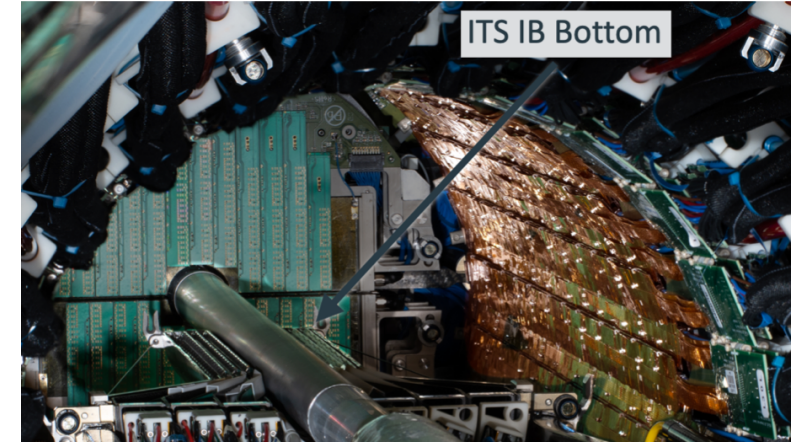
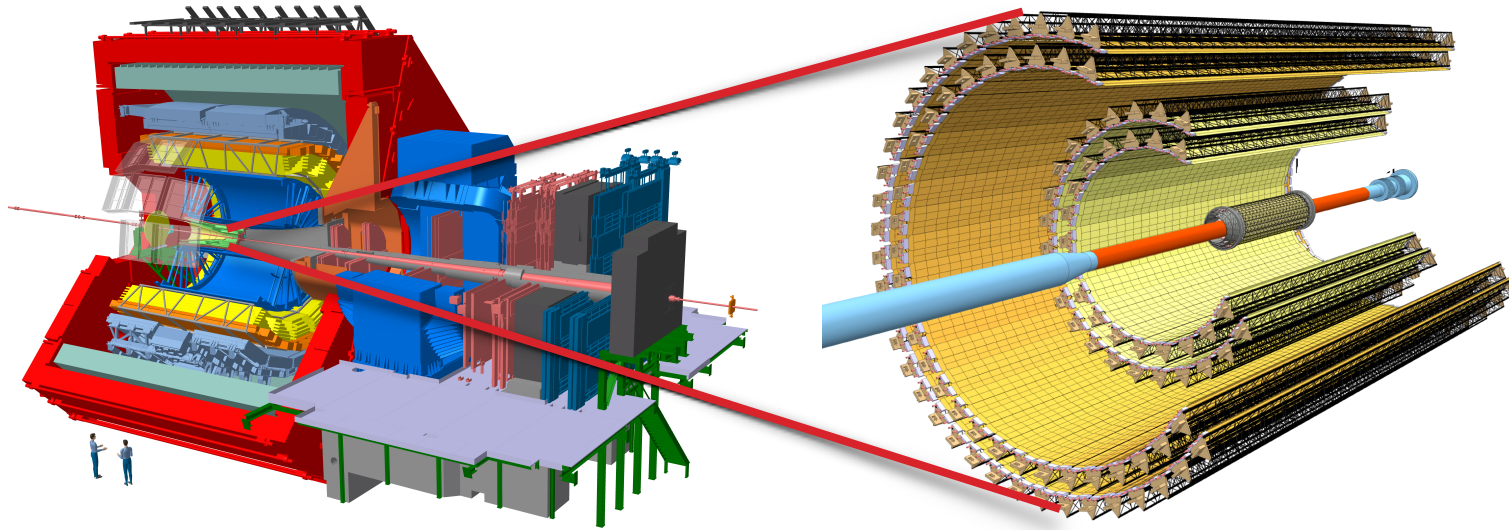
*Fudan University. June 4th, 2024.





ALICE

ALICE Inner Tracking System in Run 3 (ITS2)



7 Layers:

→ 3 inner barrel (IB) and 4 outer barrel (OB)

Large active area and granularity

→ 10m² active silicon area, 12.5 x 10⁹ pixels

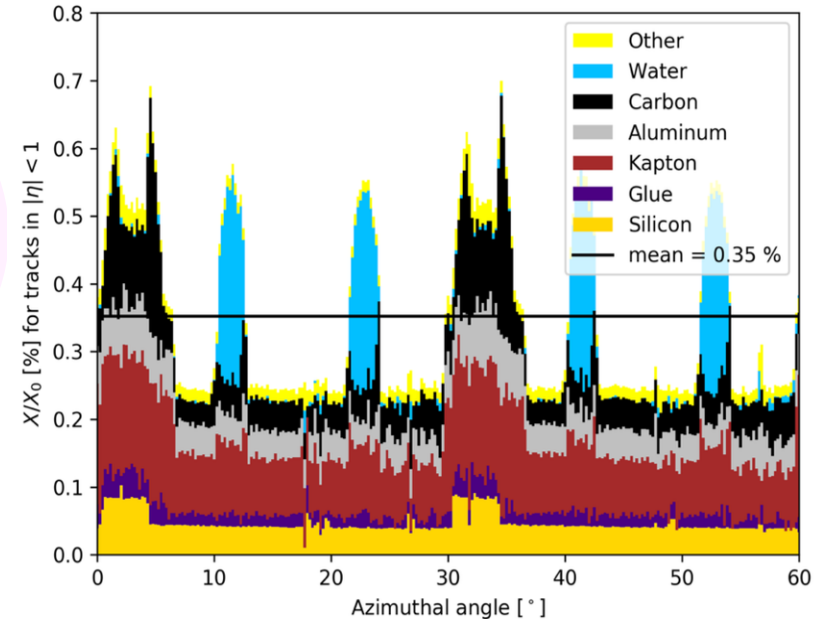
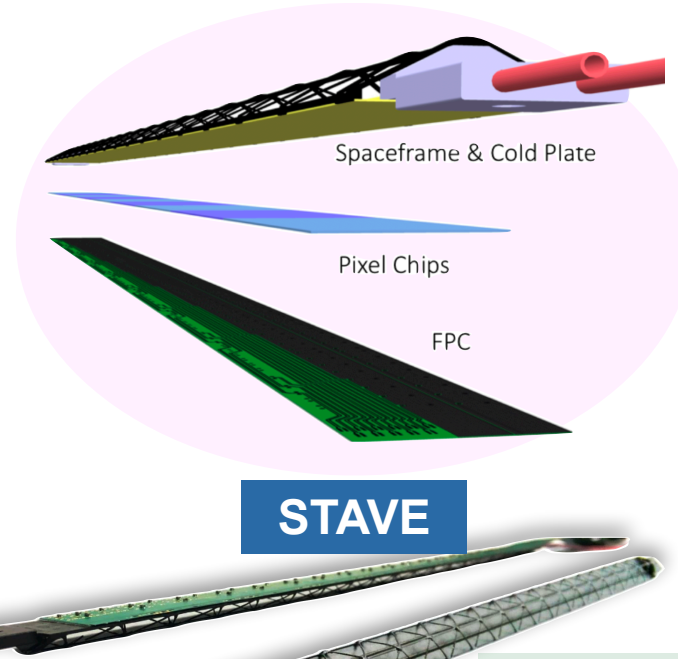
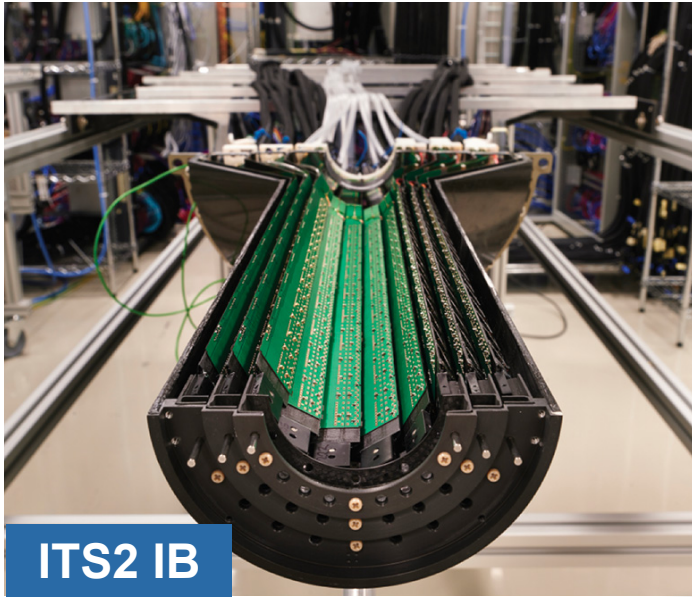
Built with ALPIDE chips

→ 180nm CMOS MAPS, 15 x 30 mm², 512 x 1024 pixels

* [M. Mager, for ALICE Collab, NIM-A 824, 434 \(2016\)](#) * [F. Reidt, for ALICE Collab, NIM-A 1005, 121793 \(2021\)](#)

LHC LS2			LHC RUN3				LHC LS3			LHC RUN4			
2019	2020	2021	2022	2023	2024	2025	2026	2027	2028	2029	2030	2031	2032

How to improve ITS2?



Non-sensitive material

- ➔ Silicon has 1/7 of total material budget

Non-uniformly distributed material

- ➔ Stave overlapping, support and water cooling structure

Unable to be closer to the interaction point

- ➔ Mechanical constraints

Remove water cooling

New process chip (with lower power consumption) required to introduce air cooling

Remove the circuit board

New technology required to integrate data, control and power distribution on a single chip

Remove of mechanical support

New mechanical structure design required

ITS3: replacement of ITS2 inner barrel

Bent wafer-scale sensor ASIC

- ➔ 65 nm CMOS MAPS
- ➔ Fabricated with stitching
- ➔ Power density < 40 mW/cm²

3 layers with 6 sensors

Air cooling between layers

Key benefit

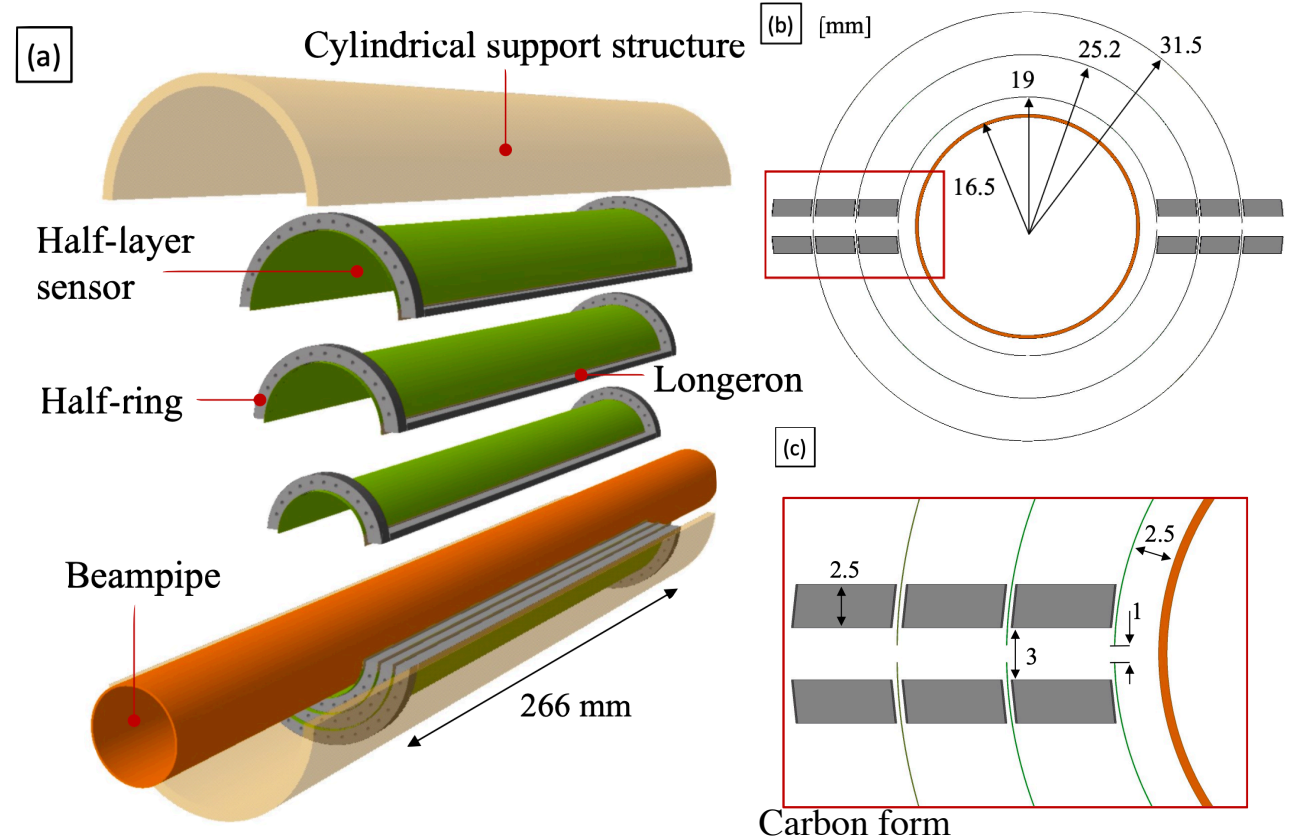
Lower material budget

- ➔ 0.35% X_0 → 0.07% X_0 per layer

Uniformly distributed material

Closer to interaction point

- ➔ Beampipe: 18.2 mm → 16.0 mm
- ➔ Layer 0 position: ~24 mm → 19.0 mm



ITS3 TDR: [CERN-LHCC-2024-003](https://cds.cern.ch/record/2811111/files/CERN-LHCC-2024-003)

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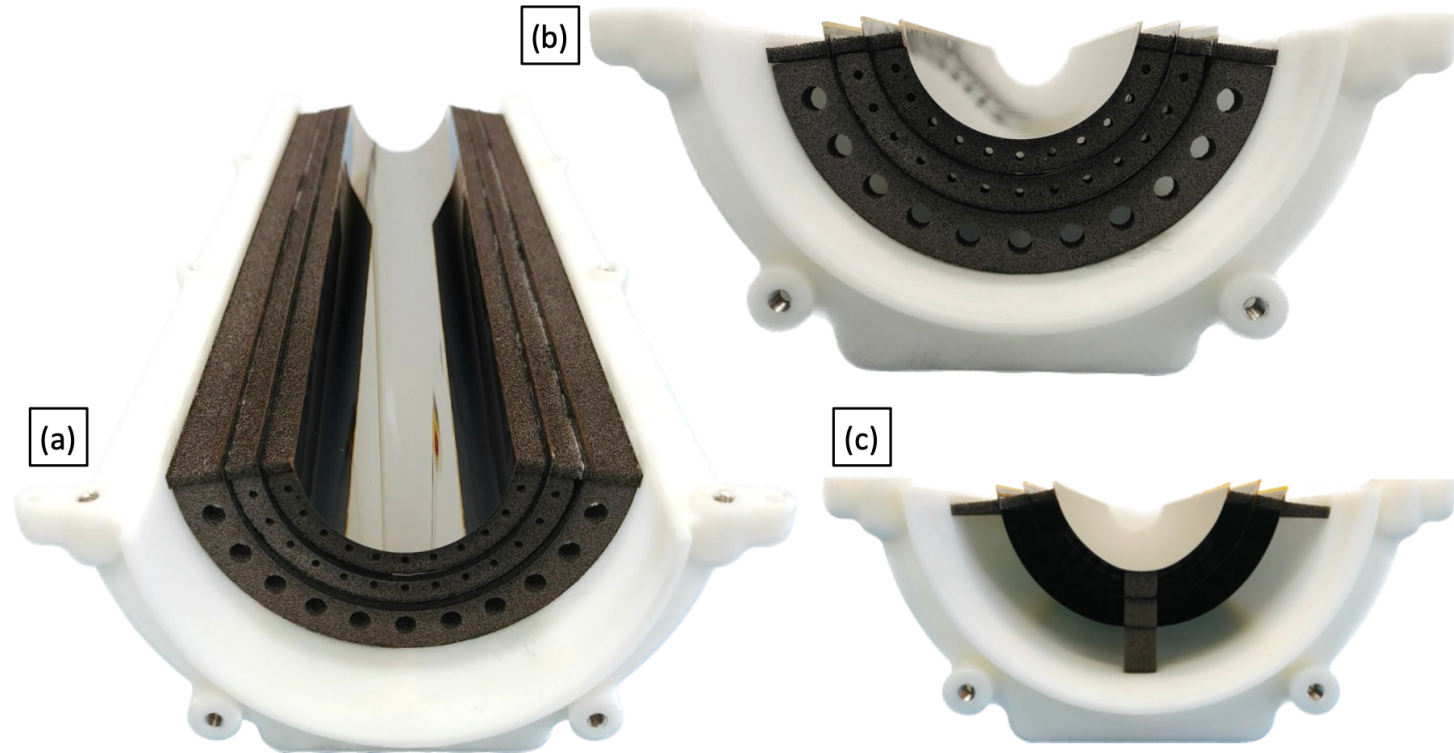
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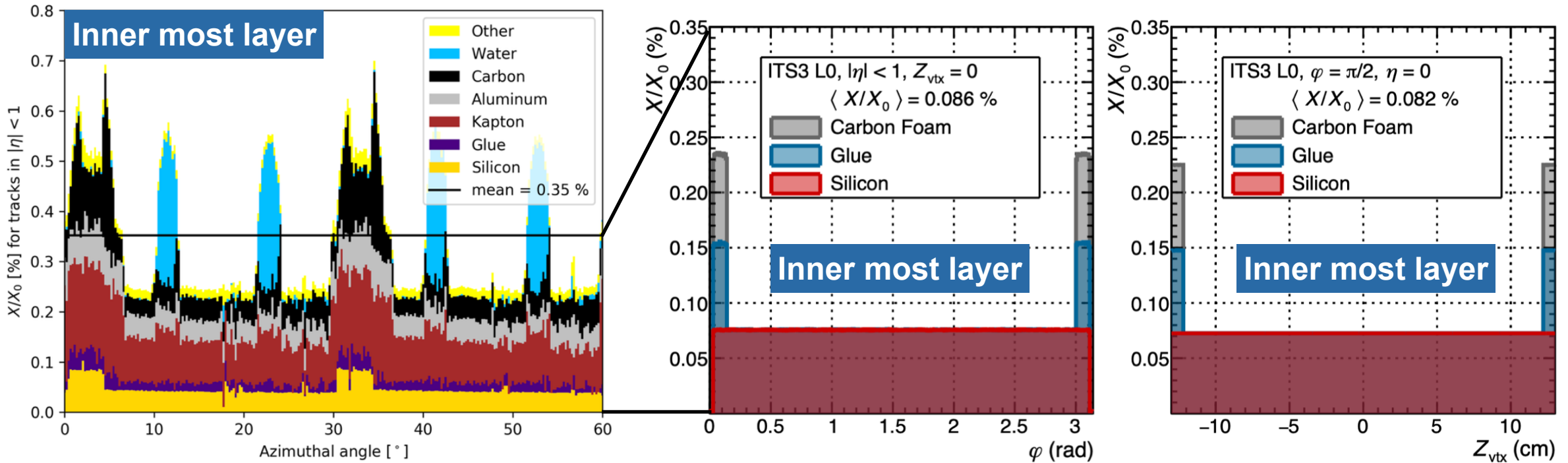
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LHC LS2			LHC RUN3				LHC LS3			LHC RUN4			
2019	2020	2021	2022	2023	2024	2025	2026	2027	2028	2029	2030	2031	2032

Material budget comparison between ITS2 IB and ITS3



ITS2 IB

Various non-sensitive material

Silicon has 1/7 of total material budget.

Non-uniformly distributed material

Stave overlapping, support and water cooling structure.

ITS3

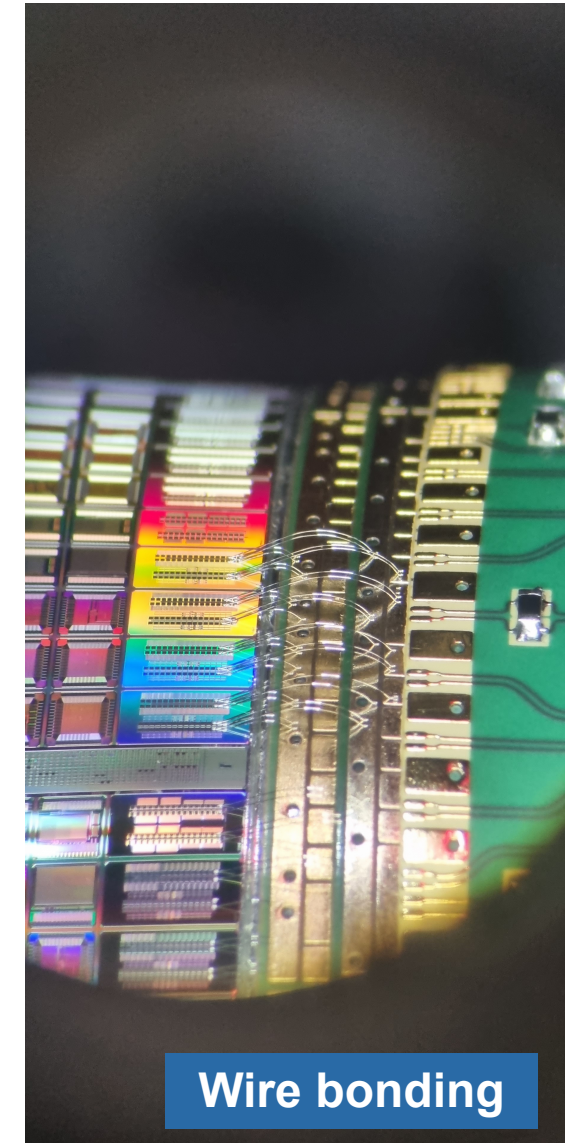
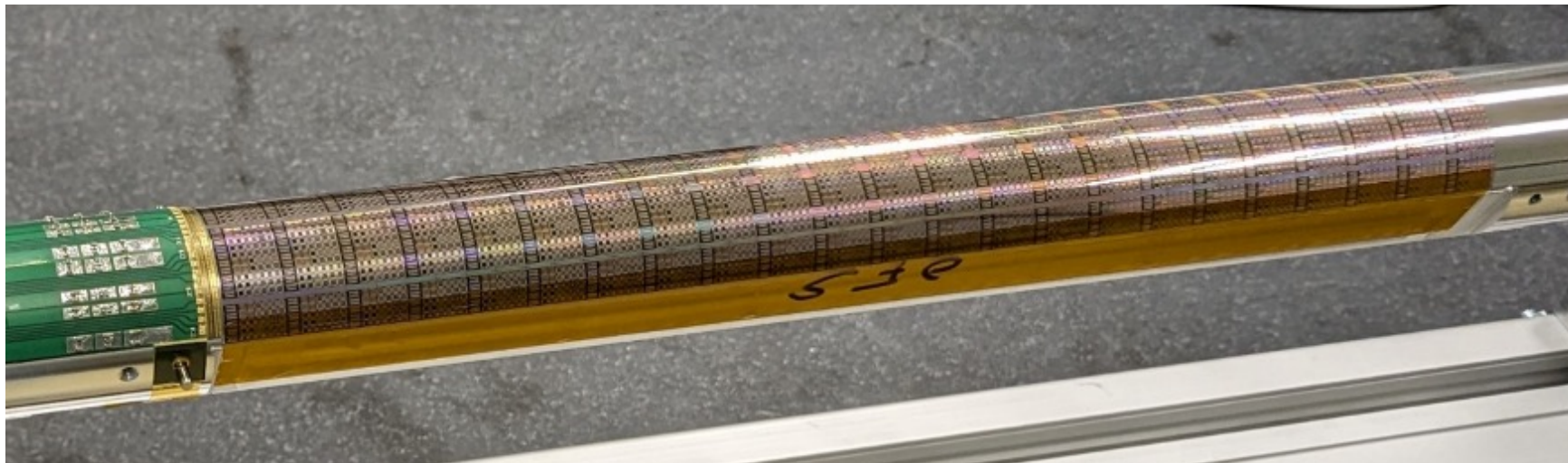
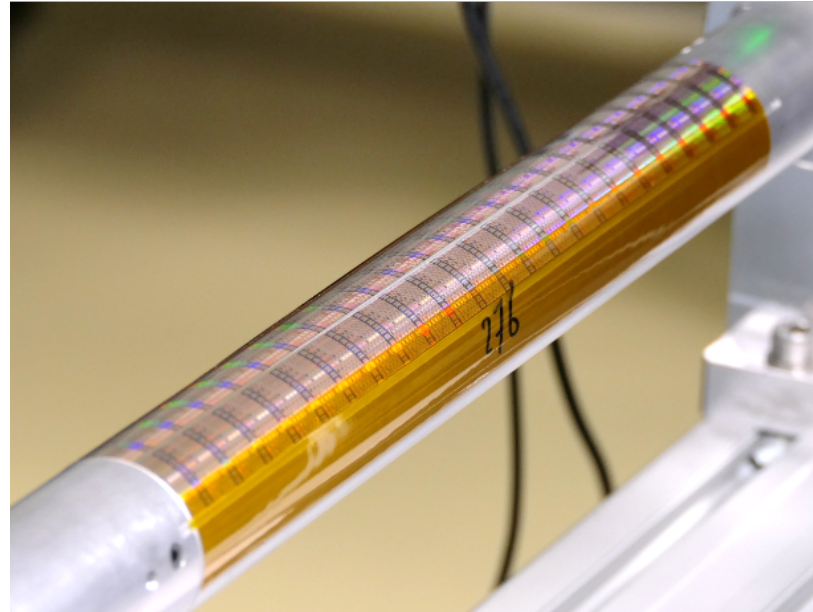
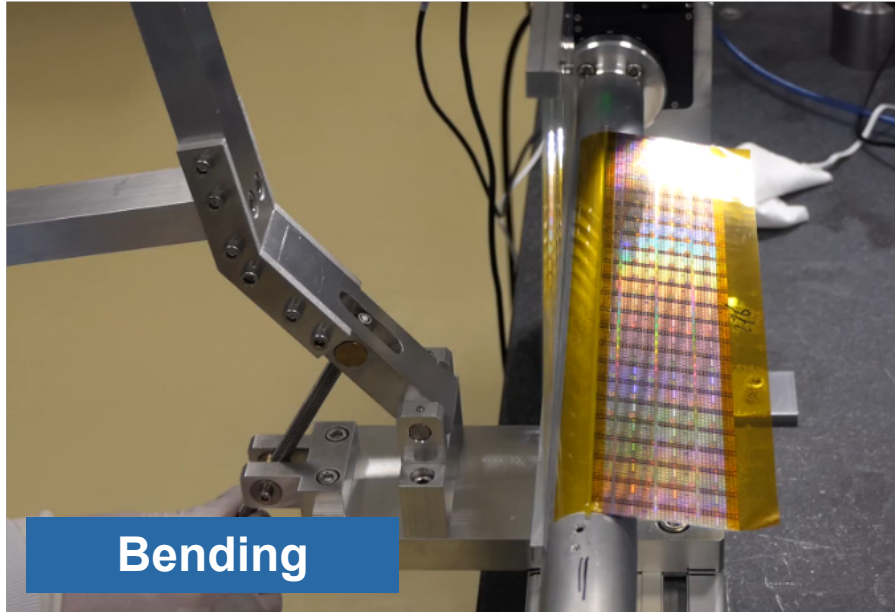
Few of non-sensitive material

Silicon dominates.

Uniformly distributed material

Only some lightweight carbon foam and glue distributed on the edge of the sensitive area.

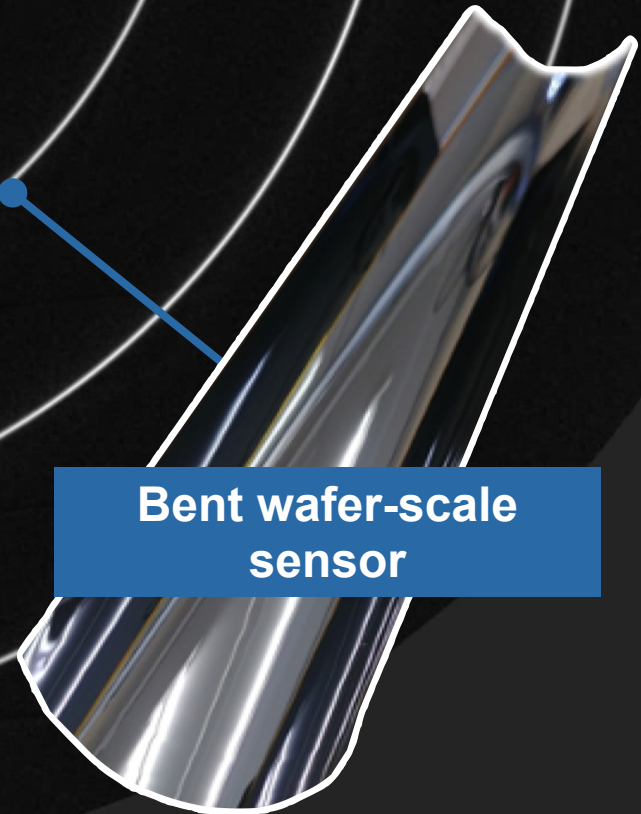
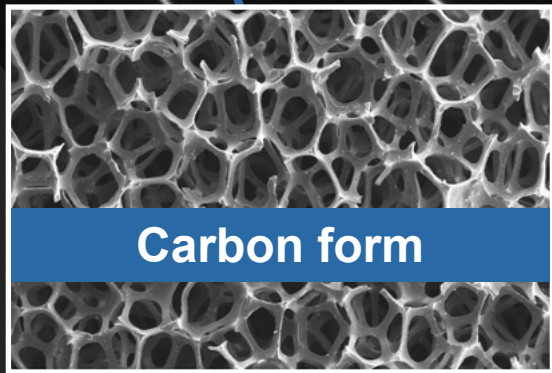
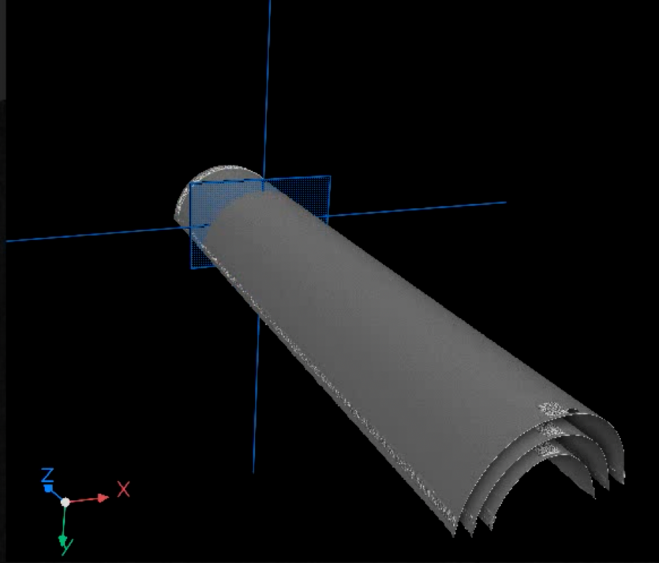
Half-layer bending and electrical integration



X-ray CT



ALICE



* Image courtesy of ITS3-WP5 (Working package on Mechanics and Cooling)

7.5 mm

Chip development roadmap

MLR1 (Multi-reticle Layer Run 1)

- **First 65nm process MAPS**
- APTS, DPTS, CE65
- Successfully qualified the 65nm process for ITS3

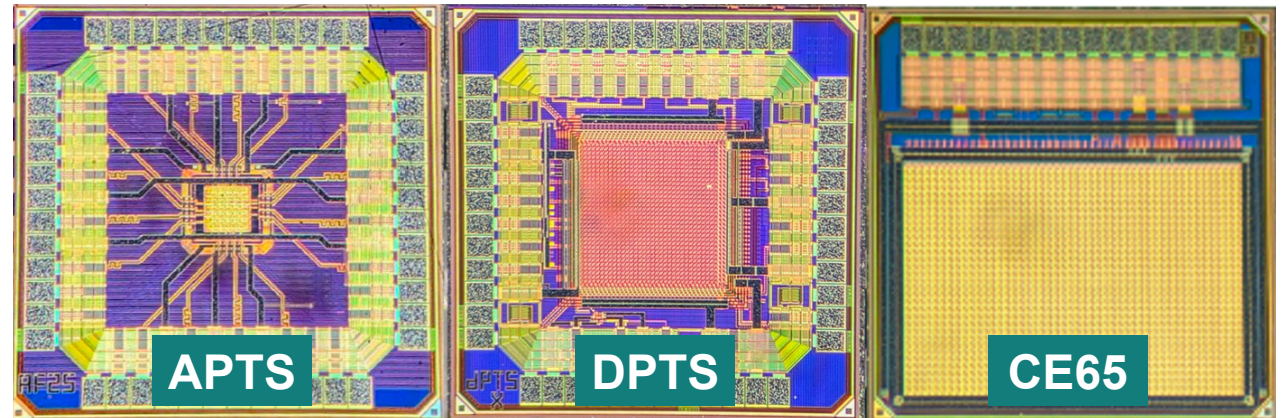
ER1 (Engineering Run 1)

- **First stitched MAPS**
- MOSS, MOST
- Successfully qualified the large scale sensor design

ER2 (Engineering Run 2)

- **ITS3 sensor prototype**
- Specifications frozen
- Design ongoing

ER3 ITS3 sensor production



APTS

Analogue Pixel Test Structure

DPS

Digital Pixel Test Structure

CE65

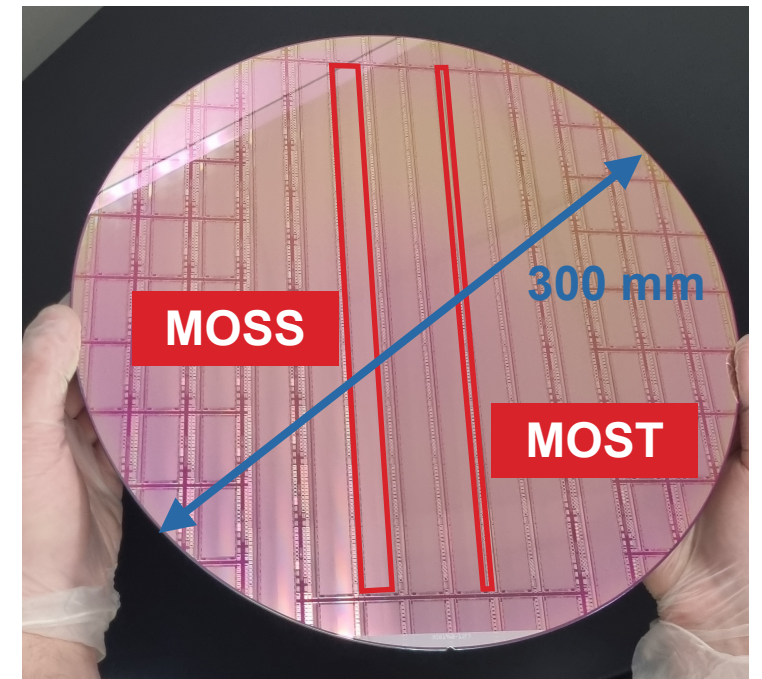
Circuit Exploratoire 65 nm

MOSS

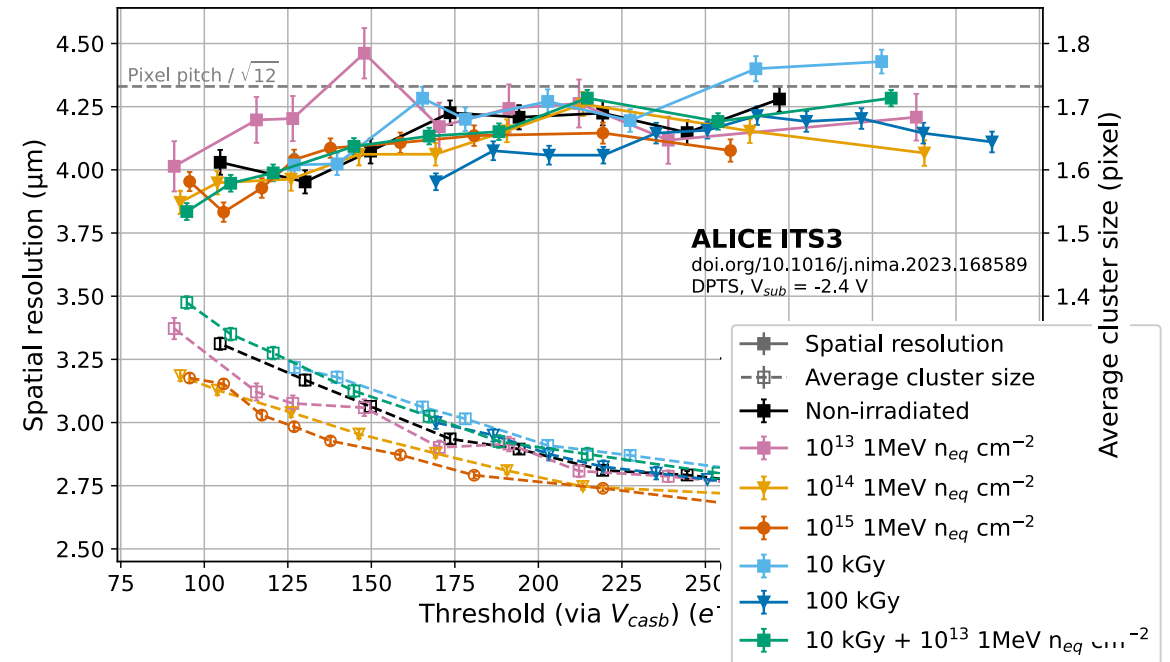
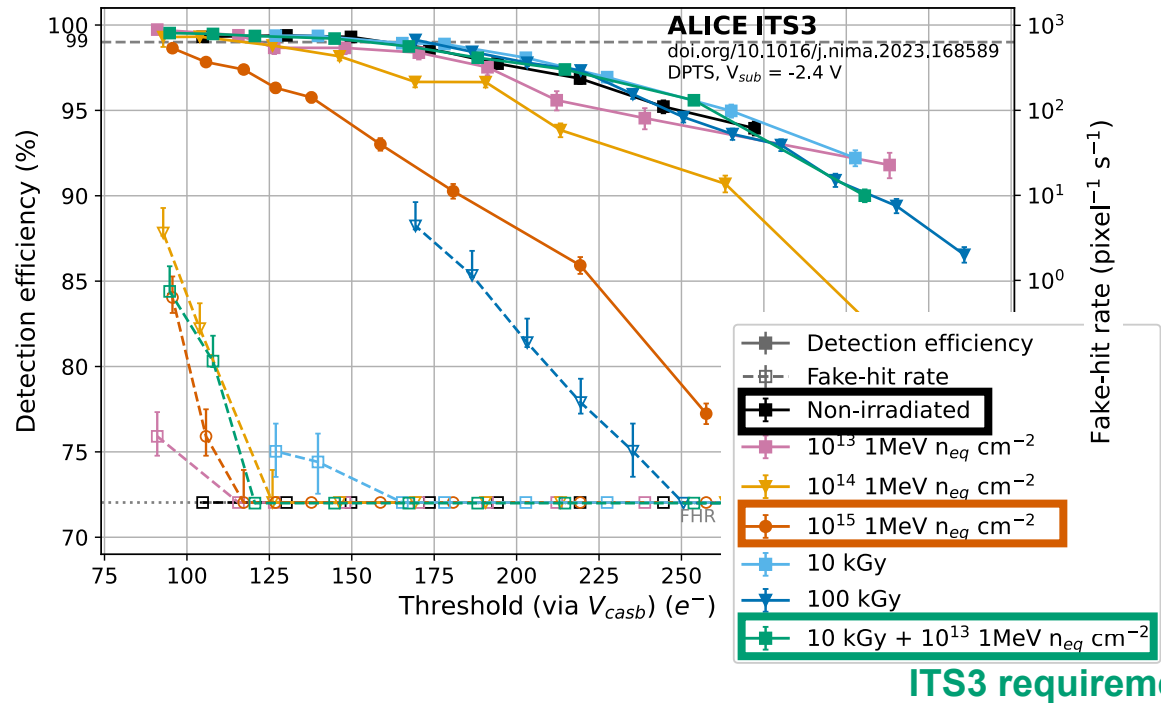
Monolithic Stitched Sensor

MOST

*Monolithic Stitched Sensor
Timing*



MLR1 testing results (selected)



- Radiation hardness assessed

- Under the irradiation requirements of ITS3, and even under higher levels, the chip operates normally

- Spatial resolution and cluster size

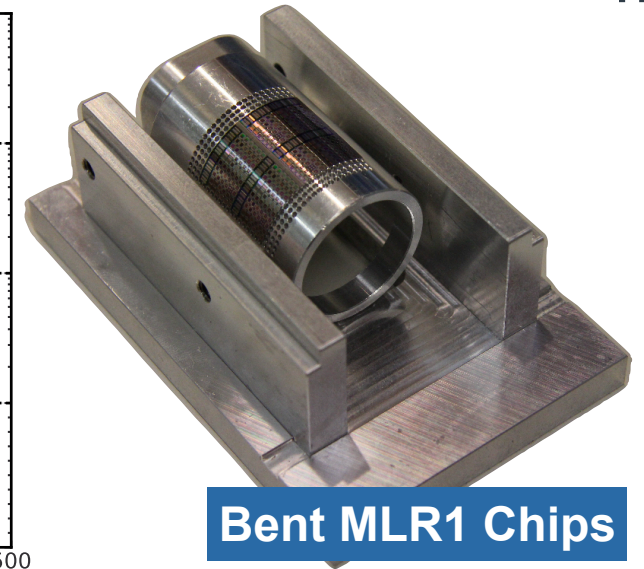
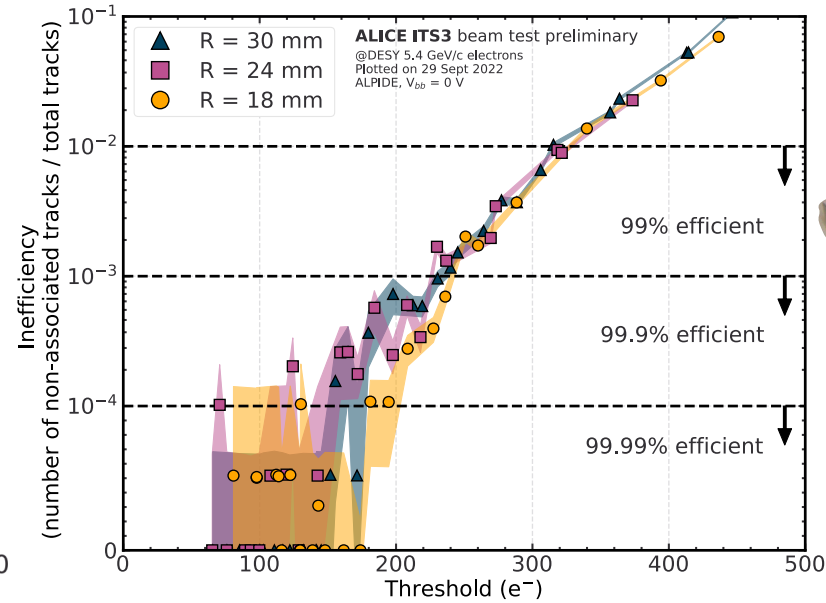
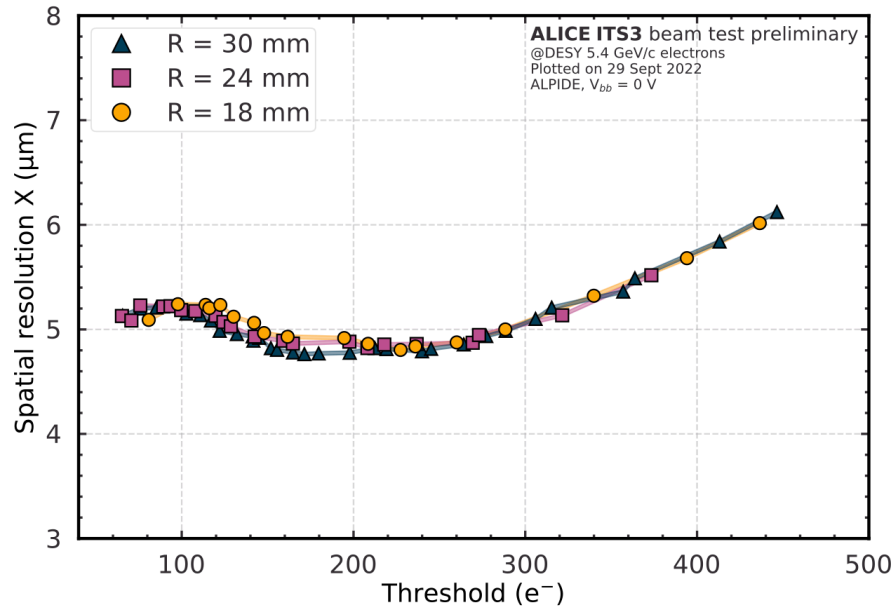
- evaluated for different levels of irradiation: spatial resolution not affected by irradiation, average cluster size slightly increase with irradiation

* [G. A. Rinella et al., NIM-A 1056, 168589 \(2023\)](#)

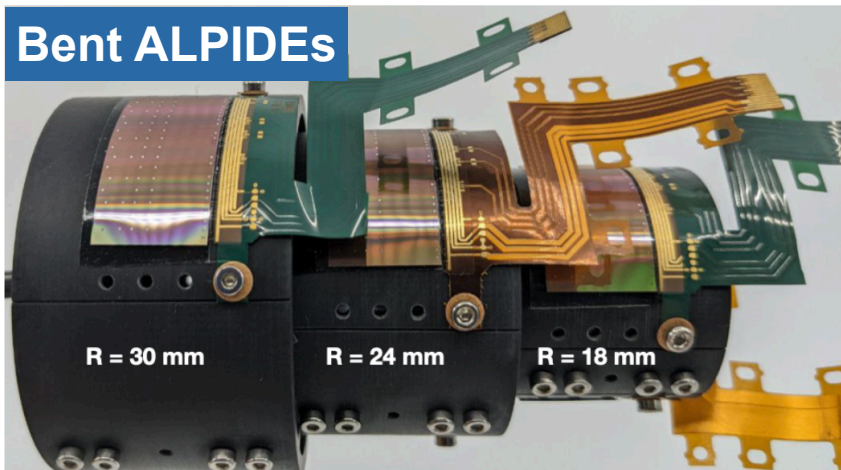
* [G. A. Rinella et al., arXiv:2403.08952](#)

Excellent performances of the 65 nm technology have been established experimentally!

Bent MAPS characterization



Bent ALPIDEs



- No performance degradation observed when bending
 - Spatial resolution of $5\mu\text{m}$ consistent with flat ALPIDEs
 - Efficiency $> 99.99\%$ for nominal operating conditions
 - Inefficiency compatible with flat ALPIDEs
- MLR1 chips (65nm process) were also tested and the results were consistent

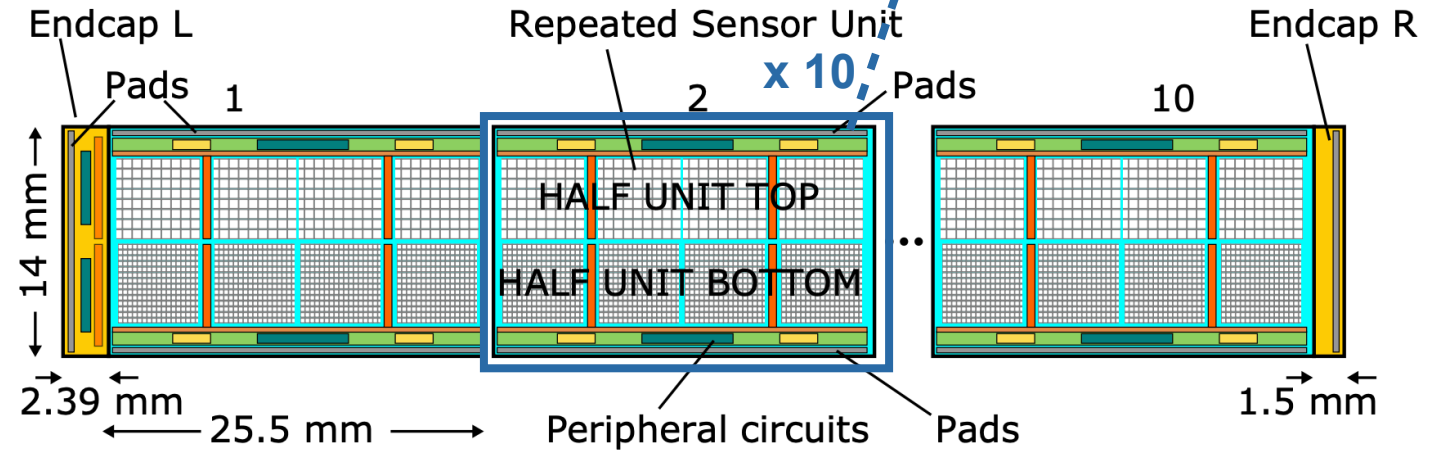
* [ALICE ITS project, NIM-A 1028, 166280 \(2022\)](#)

Bent chip work!

MOSS (ER1)

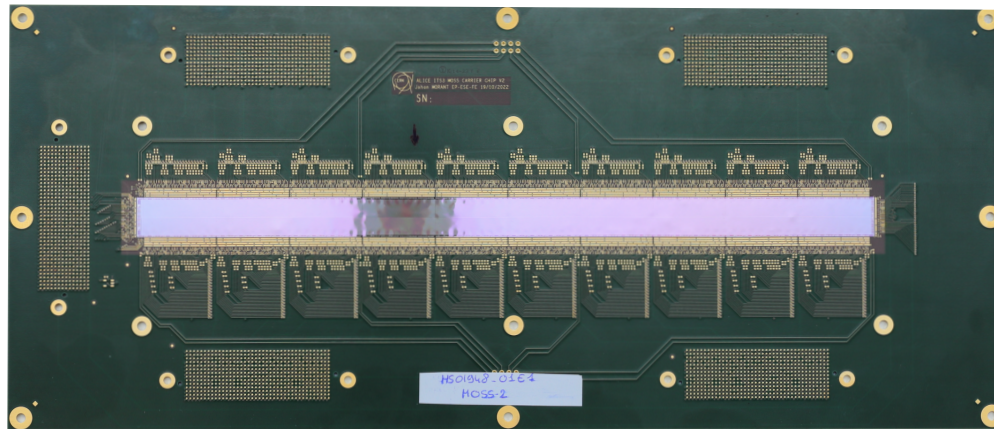
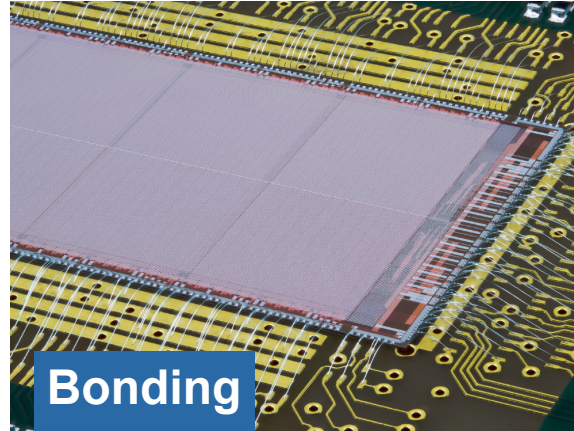
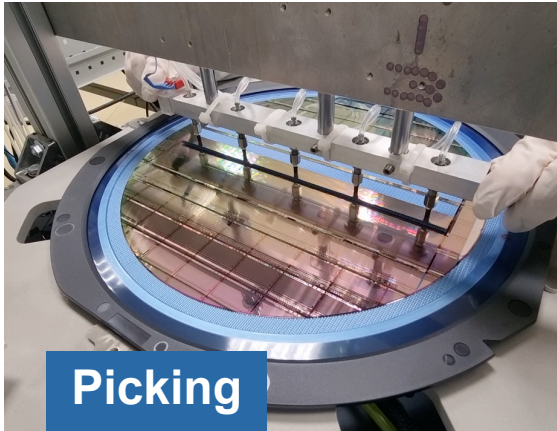


- **First stitched chips!**
- **Full module on a single chip**
- **Wafer-scale (14 x 259 mm), 6.72 million pixels**
- **MOSS is segmented into 10 repeated sensor units (RSU)**
- **RSUs are divided into top and bottom half units with different pitches**

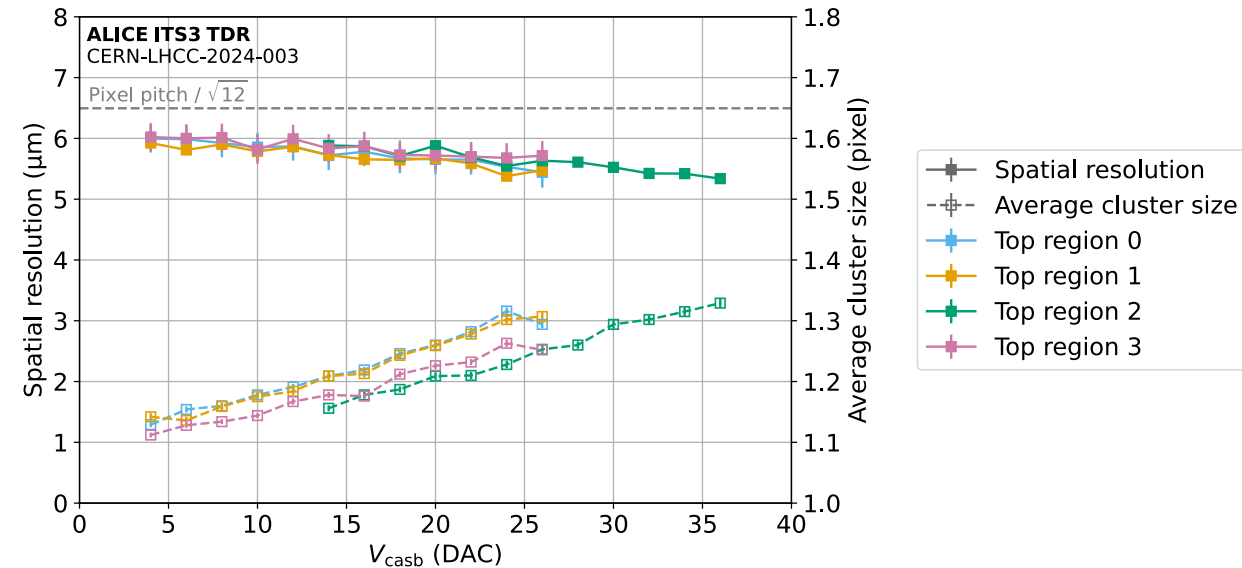
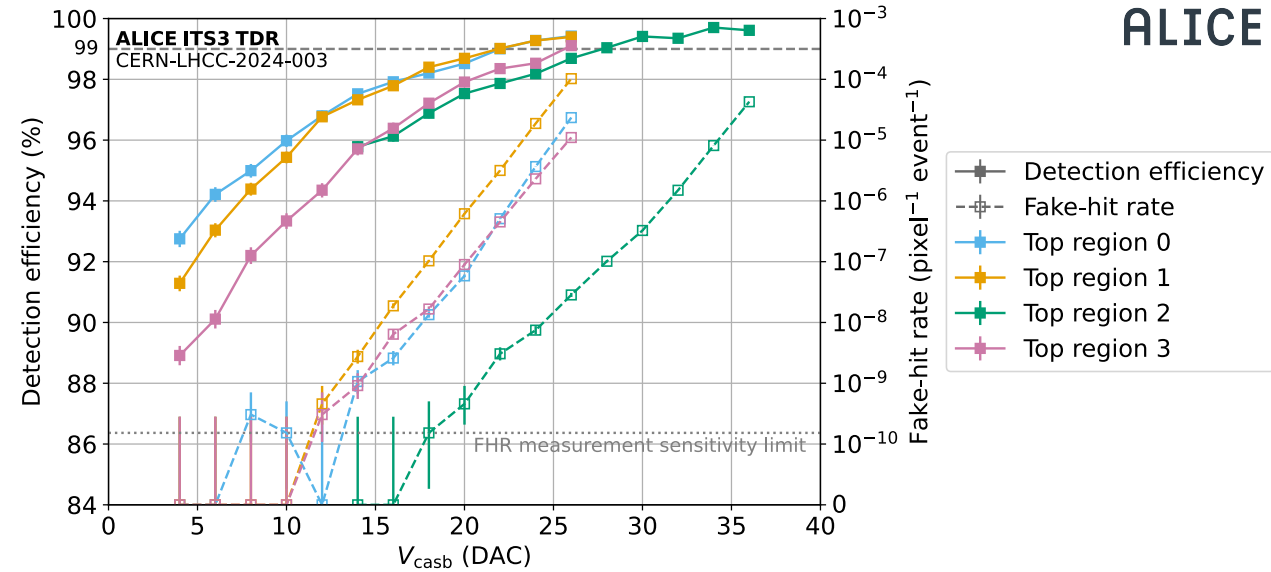


	Pixel matrix	Pixel size
Matrices on the top	256 × 256	22.5 μm
Matrices on the bottom	320 × 320	18 μm

MOSS (ER1) testing results (selected)

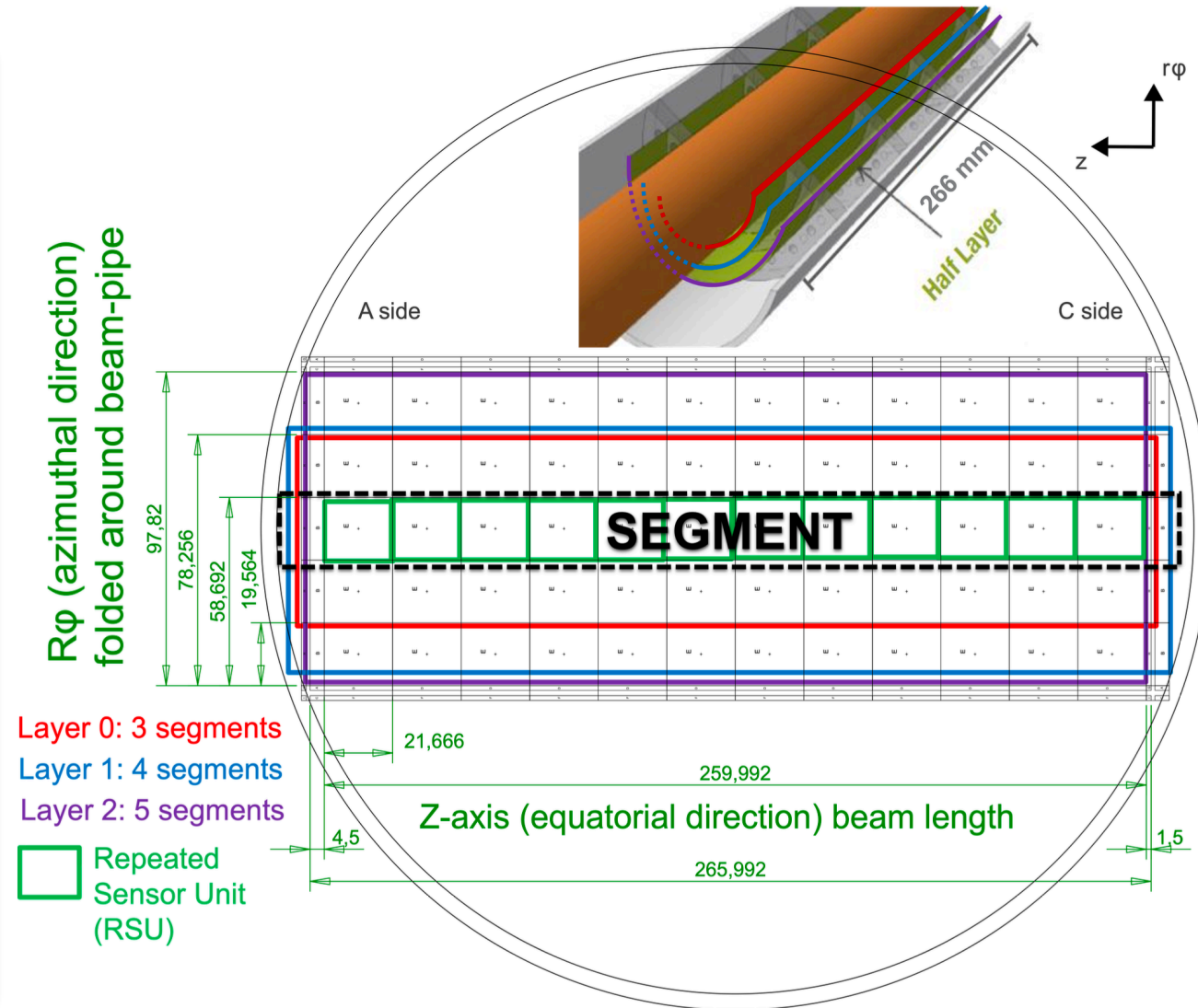
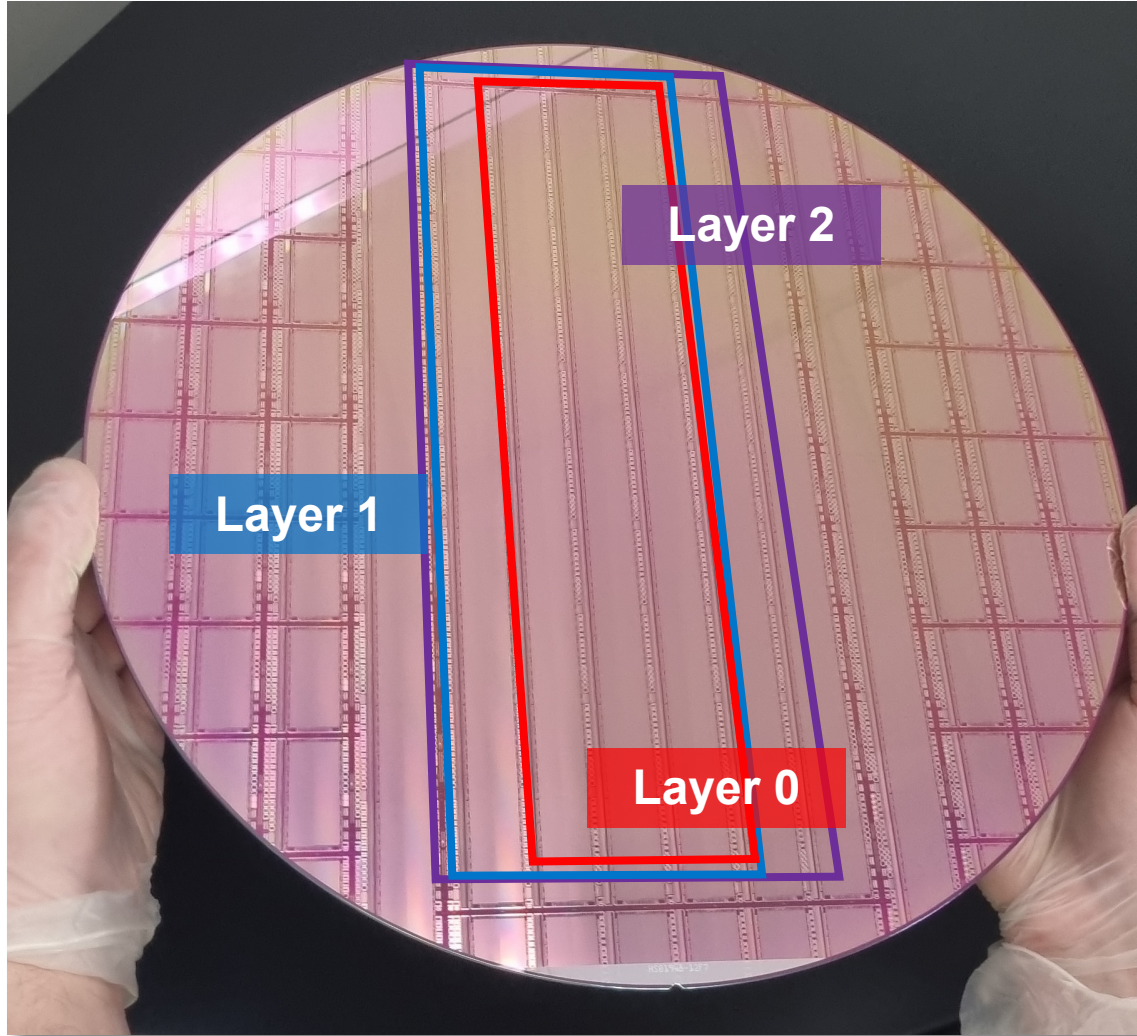


MOSS wire-bonded on the carrier card

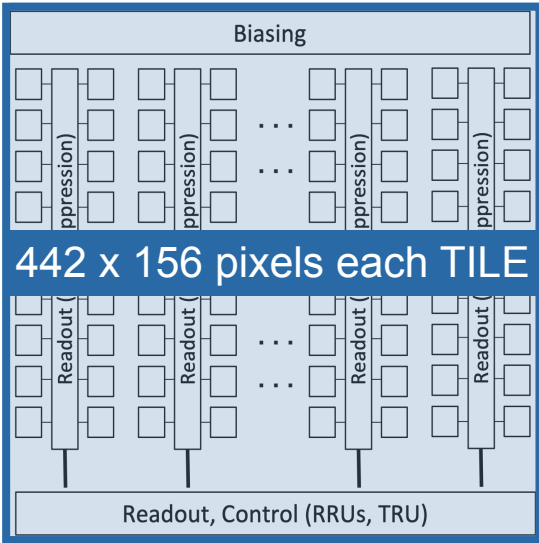


Efficiency and spatial resolutions that are expected from MLR1 chips are confirmed

Final Chip Design



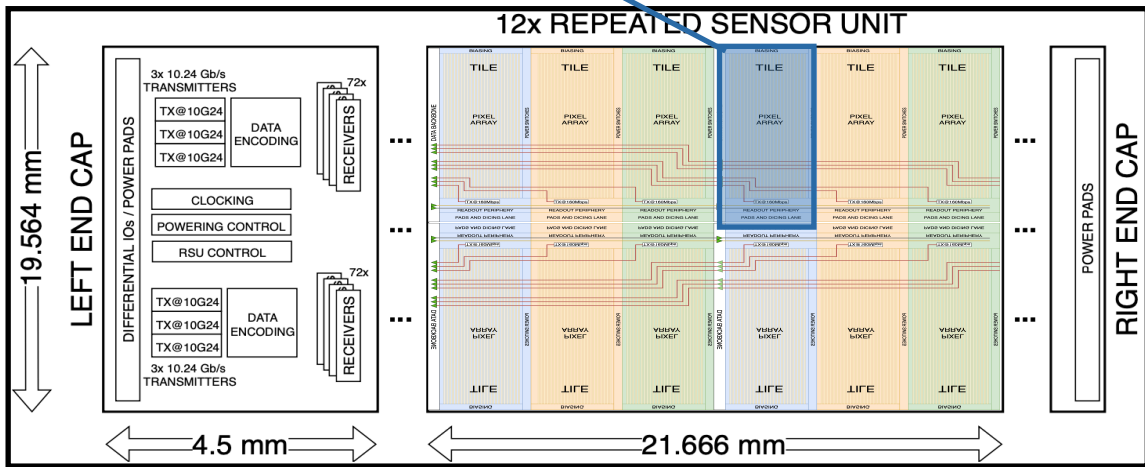
Final Chip Design



Power consumption:
40 mW/cm²

Total ITS3 Fill factor:
~93%

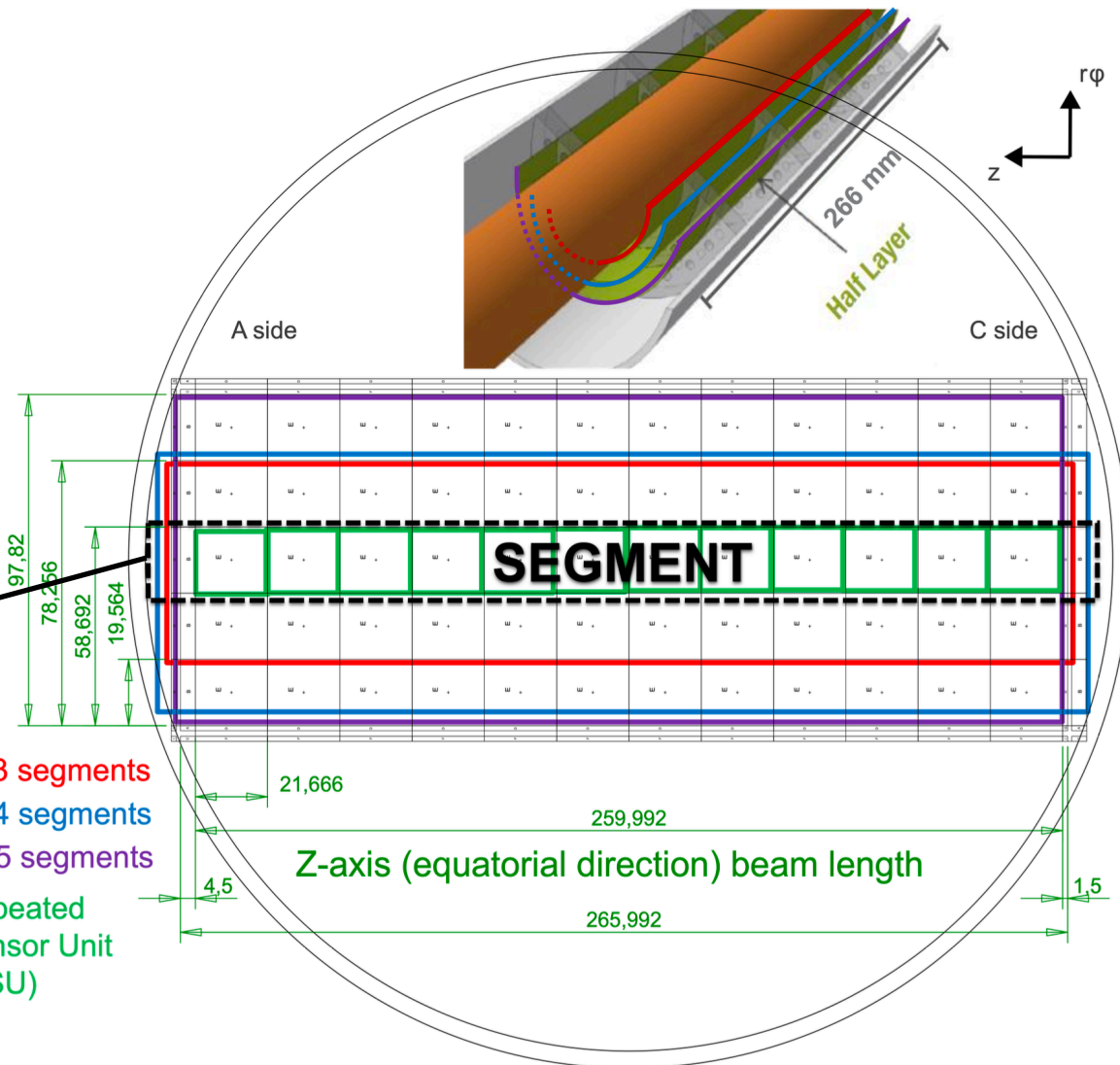
- possibly ~95.5% depending on ER2 test results.
- i.e. deadzone area: ~7%



R ϕ (azimuthal direction) folded around beam-pipe

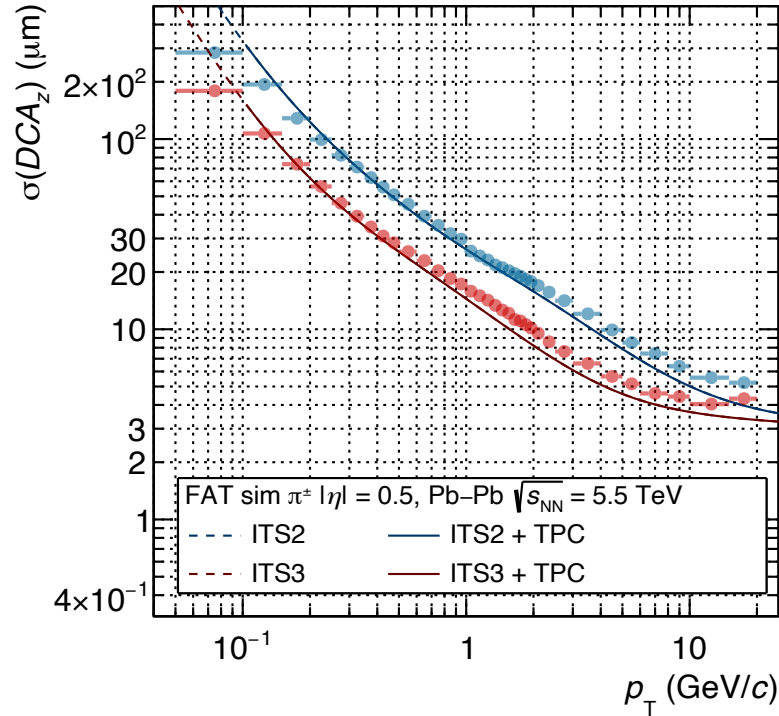
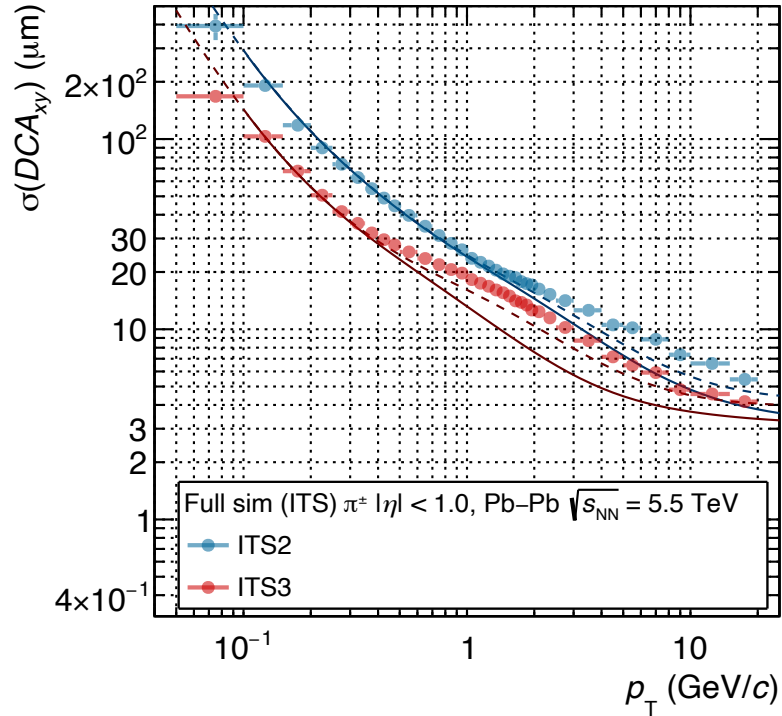
Layer 0: 3 segments
Layer 1: 4 segments
Layer 2: 5 segments

Repeated Sensor Unit (RSU)



Design is progressing well, with silicon back by early 2025

Physics performance — Single track in Pb-Pb collisions

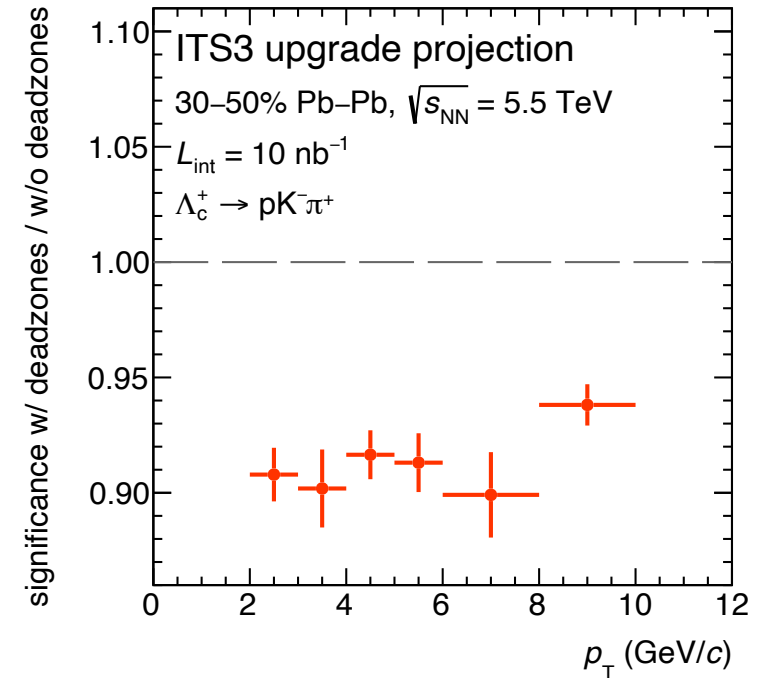
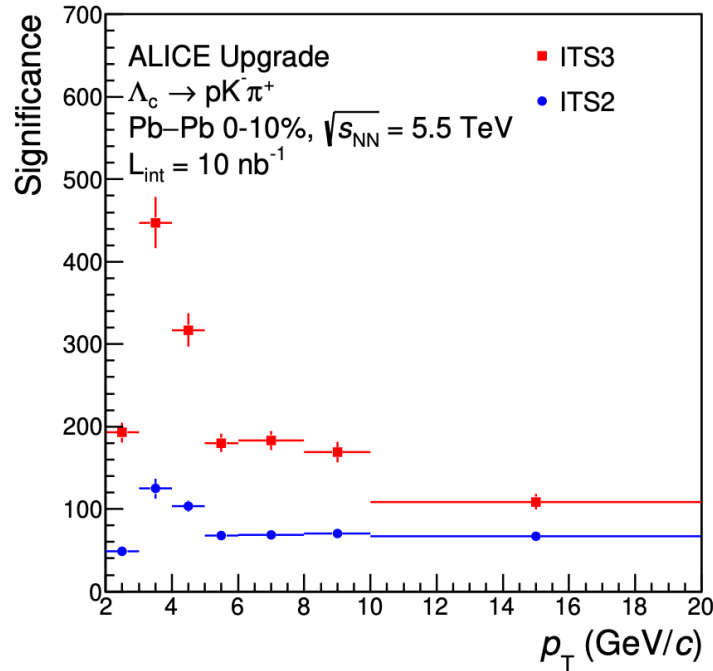
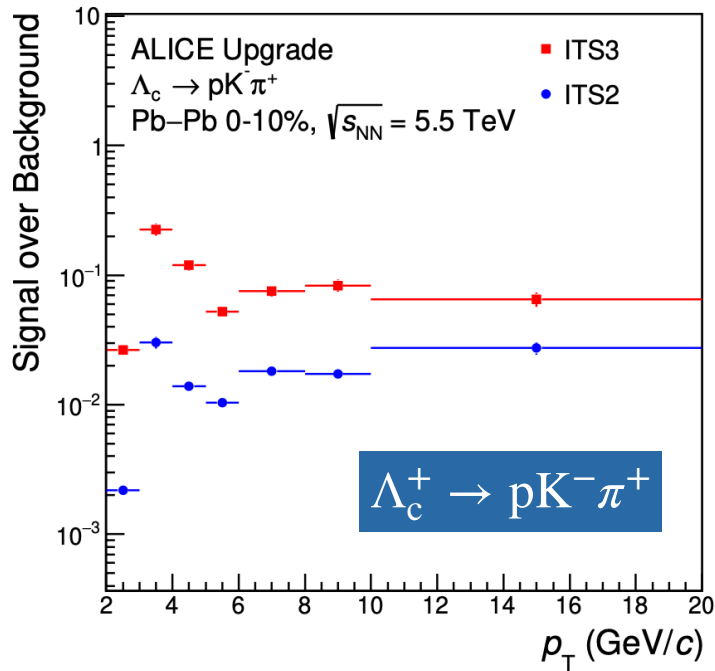


- Detailed description of geometry and material applied.
- Two simulation methods used
 - Full simulation
 - Fast simulation (FAT)

- ITS-only: Full sim and FAT results in good agreement for DCA_{xy} and DCA_z
 - Residual difference related to the material description (more accurate in full sim) or to tracking model
- Bump trend on DCA_{xy} in $0.5 < p_T < 4$ GeV/c
 - Due to p_T resolution, significantly calibrated by the introduction of TPC

A twofold improvement in spatial resolution compared to ITS2

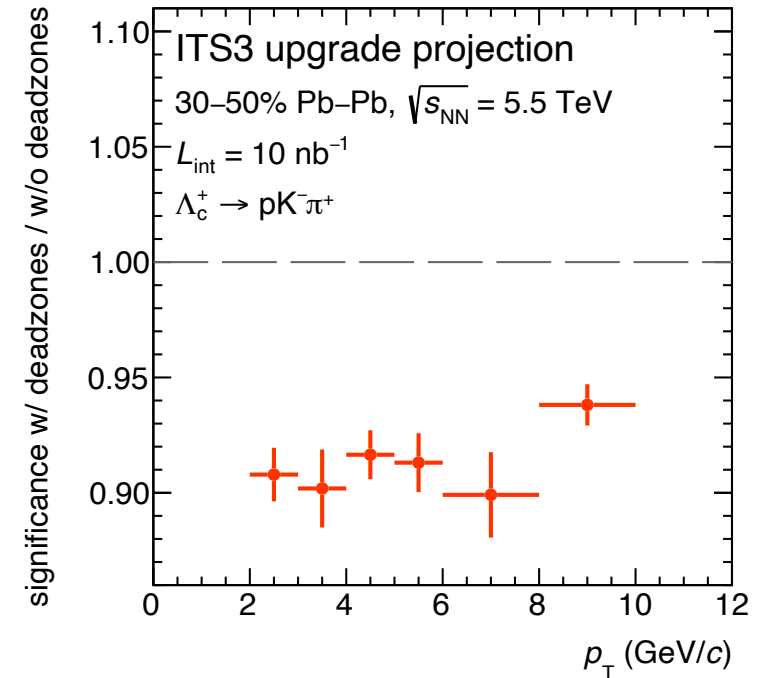
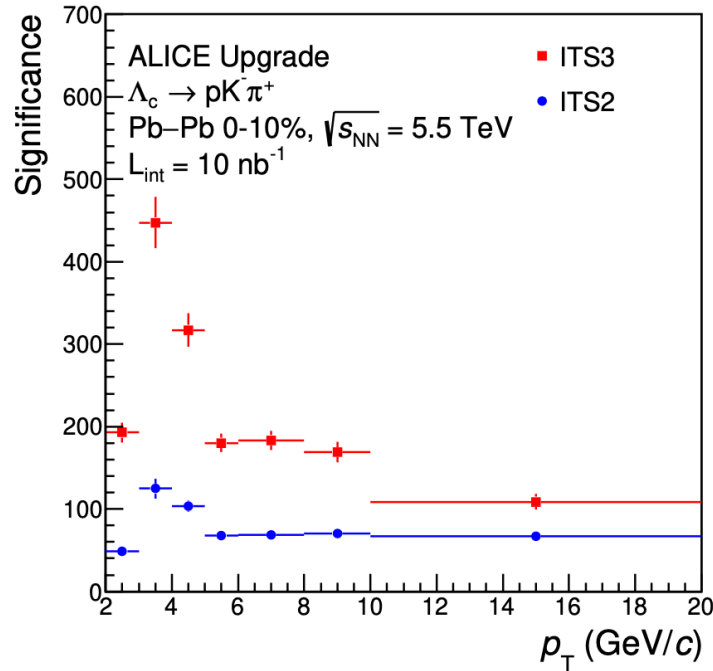
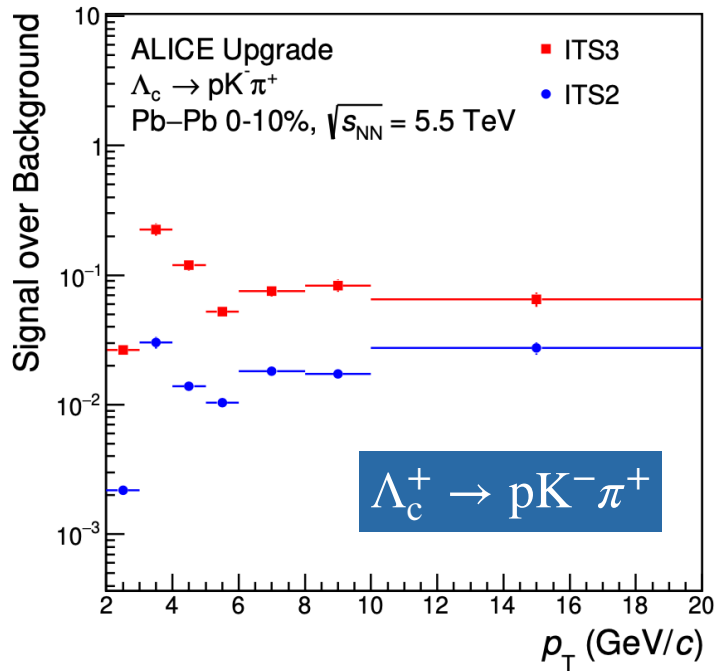
Physics performance — Heavy flavor hadron reconstruction



Public Note on ITS3 Physics Performance [ALICE-PUBLIC-2023-002](https://arxiv.org/abs/2302.002)

- Λ_c^+ reconstruction as an example
- Nice benchmark to evaluate the improvement
 - ➔ Large 3-prong combinatorial background
 - ➔ Measurement of primary and decay vertices can benefit from ITS upgrades.

Physics performance — Heavy flavor hadron reconstruction



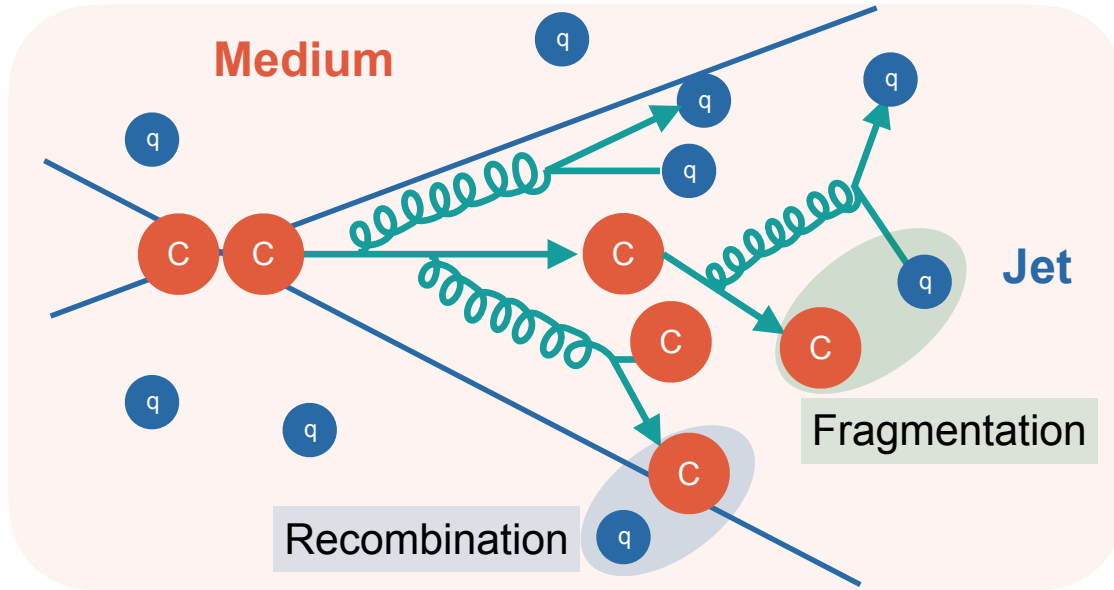
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- Λ_c^+ reconstruction as an example
- Nice benchmark to evaluate the improvement
 - ➔ Large 3-prong combinatorial background
 - ➔ Measurement of primary and decay vertices can benefit from ITS upgrades.

- A factor of ~ 10 for the improvement on the S/B
- A factor of ~ 4 for the improvement on the significance
- Impact of deadzones **negligible** compared to the improvement between ITS2 and ITS3

*Signal and background yields estimated in an invariant-mass interval of $\pm 3\sigma$ around the Λ_c^+ mass

Physics reach — Heavy flavor collectivity



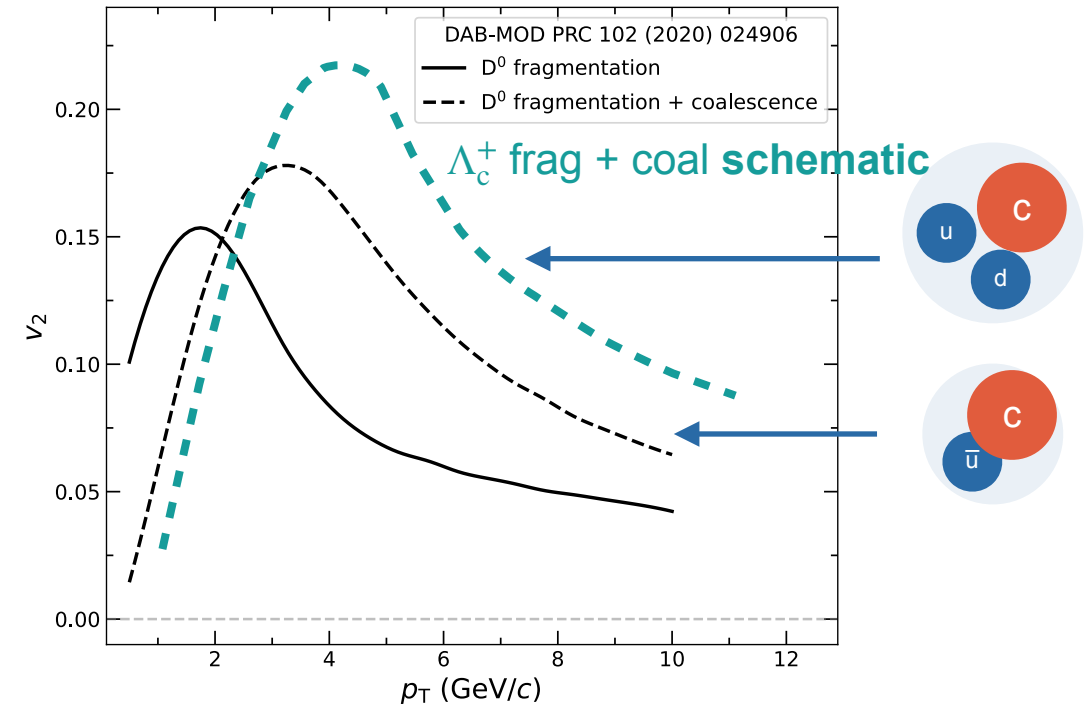
Heavy-quark hadronization from the medium

Fragmentation $D_{q \rightarrow h}(z_q, Q^2)$

A fraction of the parton momentum z_q is taken by the hadron

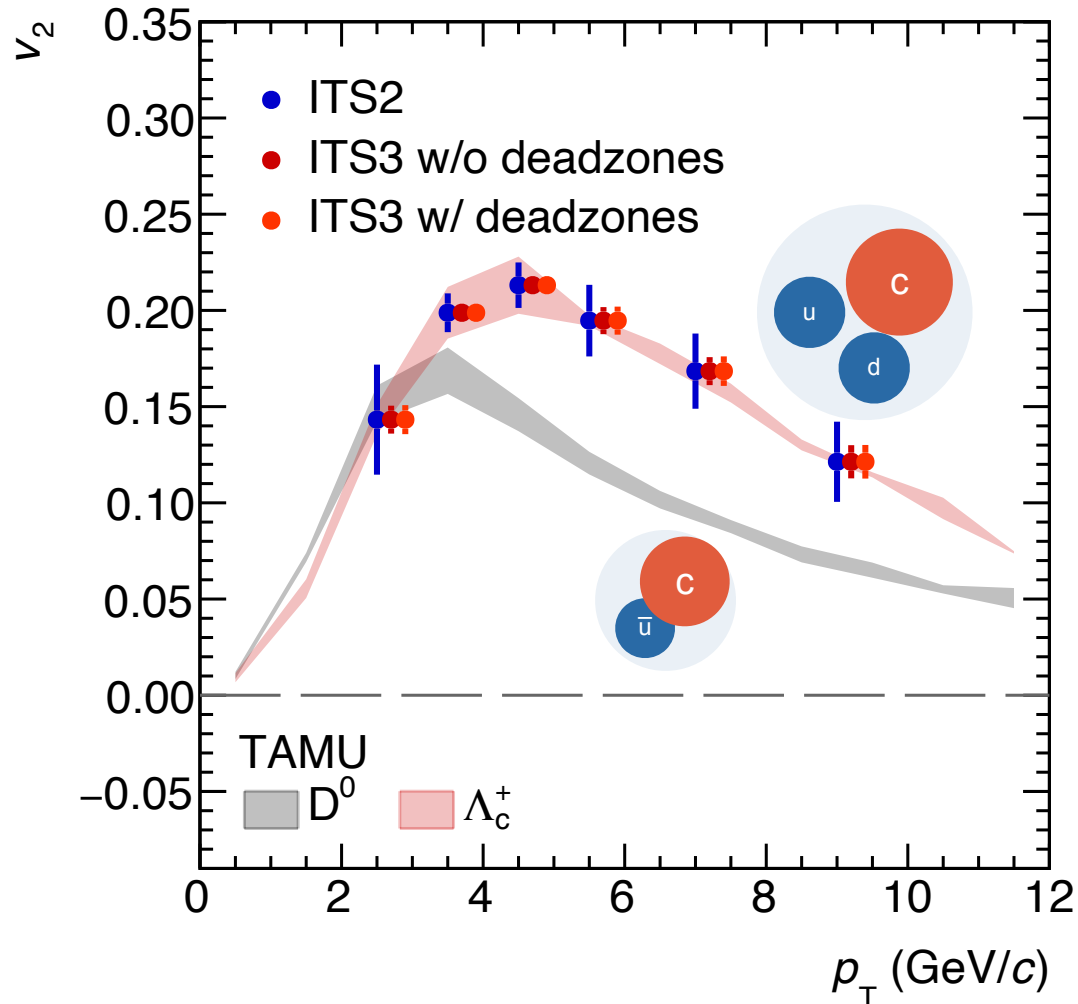
Recombination/coalescence

Partons close in phase space can recombine



- Recombination of c-quarks with the medium light quarks could cause charm hadrons to **partly inherit the flow of light quarks**.
- Λ_c^+ (udc) has one more light quark than D^0 , may inherit more "collective" characteristics of light quarks.

Physics reach — Heavy flavor collectivity



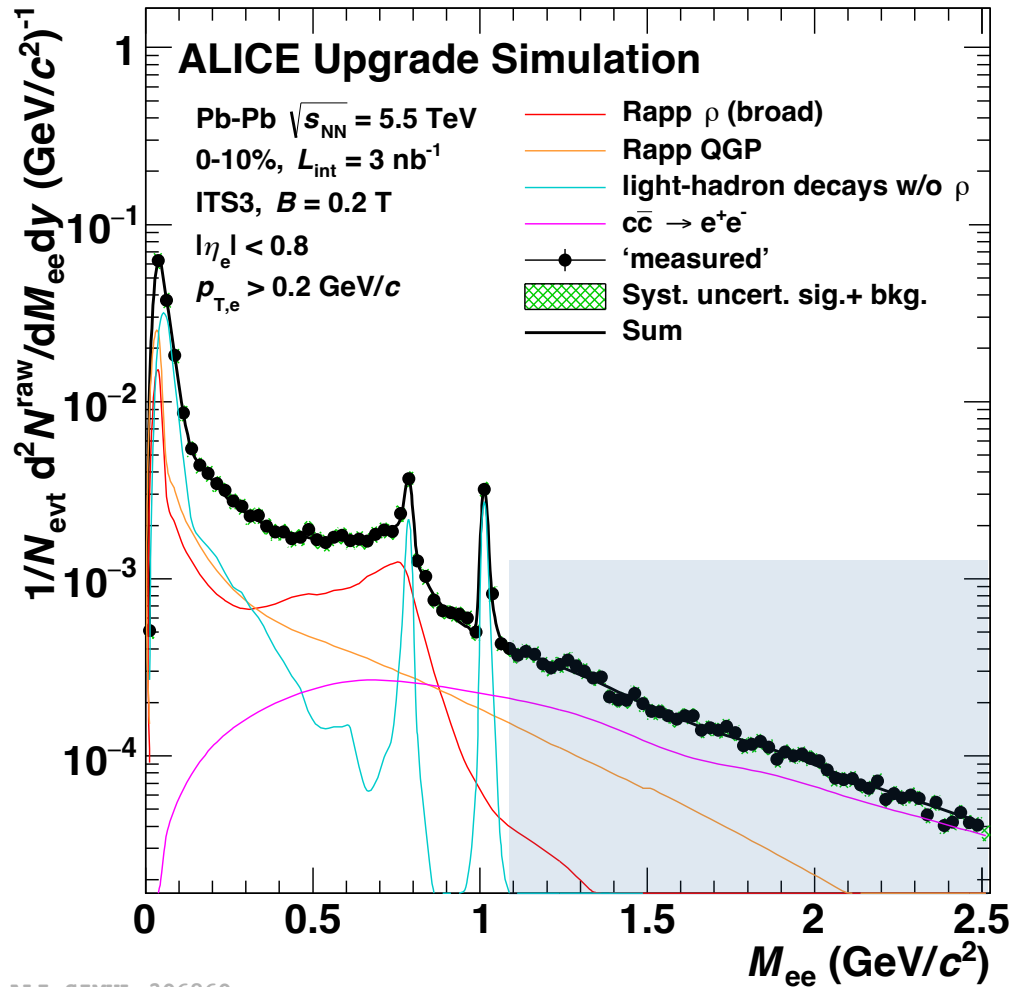
Expected to get a difference $\Delta v_2 \approx 0.03$ between D^0 and Λ_c^+ by TAMU Model*

* [M. He and R. Rapp, PRL 124, 042301 \(2020\)](#)

- Up to a factor of 4 reduction of the statistical uncertainty
- Impact of deadzones in ITS3 is negligible

Able to constrain the modeling of charm diffusion and hadronization in the QGP

Physics reach — Thermal dielectron measurement



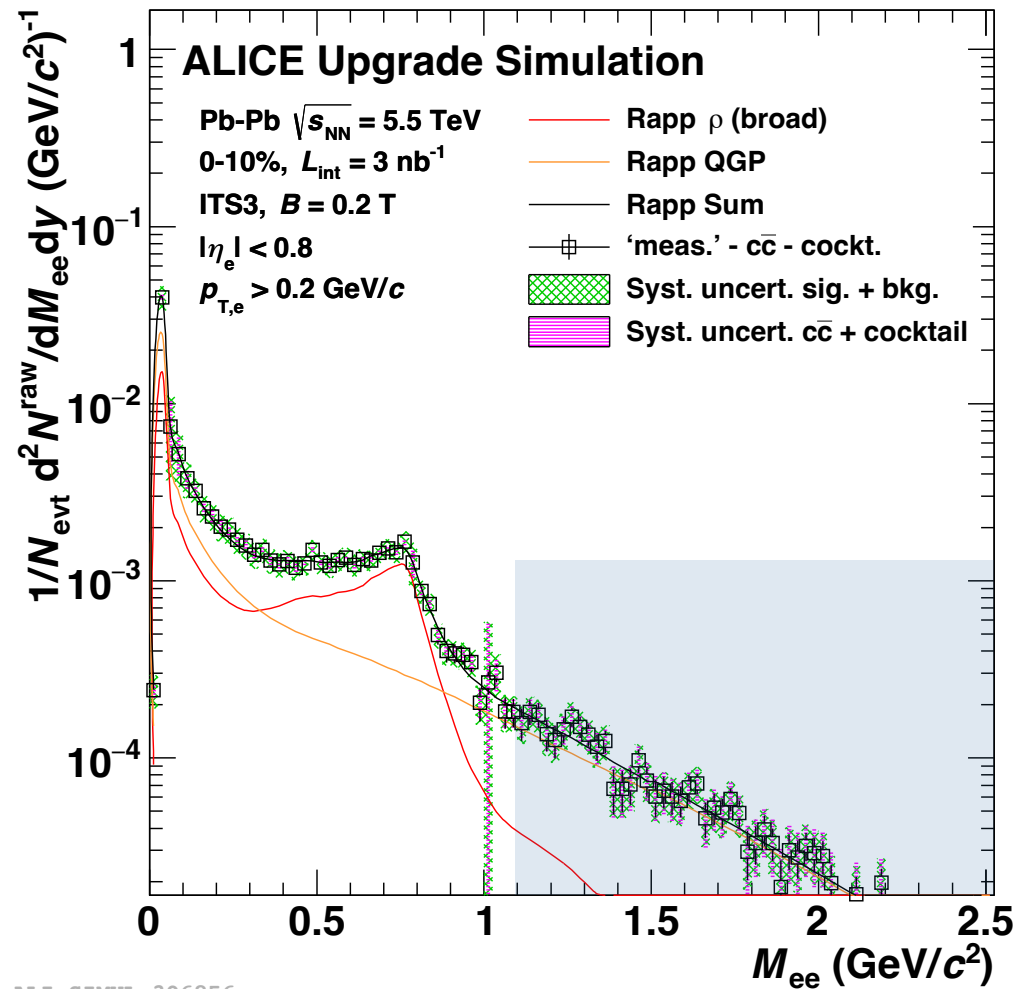
Complex invariant mass spectrum of e^+e^- pairs

- Light-flavor hadron decays
- Heavy-flavor hadron decays (suppressed using DCA to primary vertex)
- Thermal radiations:
 - from hadron gas
 - from QGP

In the region where $M_{ee} > 1.1$ GeV/c 2

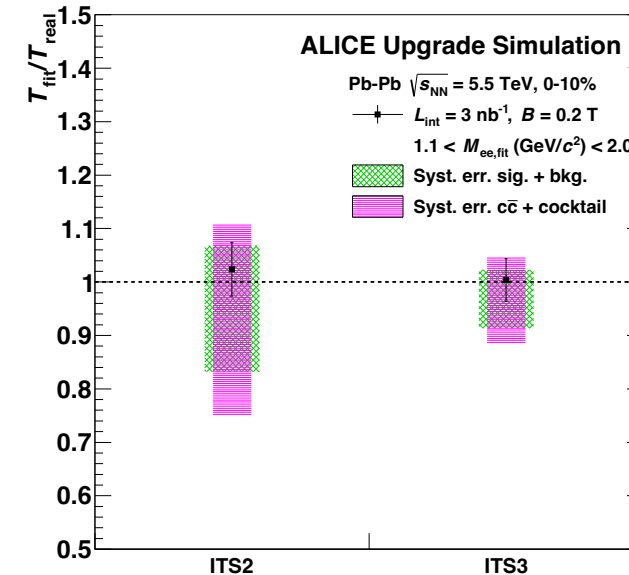
- The $c\bar{c} \rightarrow e^+e^-$ process and the thermal radiations from QGP dominate
- Suitable for extracting the QGP temperature

Physics reach — Thermal dielectron measurement



ALI-SIMUL-306856

- **Less material** results in fewer electrons from photon conversions.
- **Enhanced low- p_T electron tracking** improves photon conversion reconstruction efficiency, reducing the combinatorial background.
- **Improved DCA resolution** suppresses contributions from heavy-flavor hadron decays.



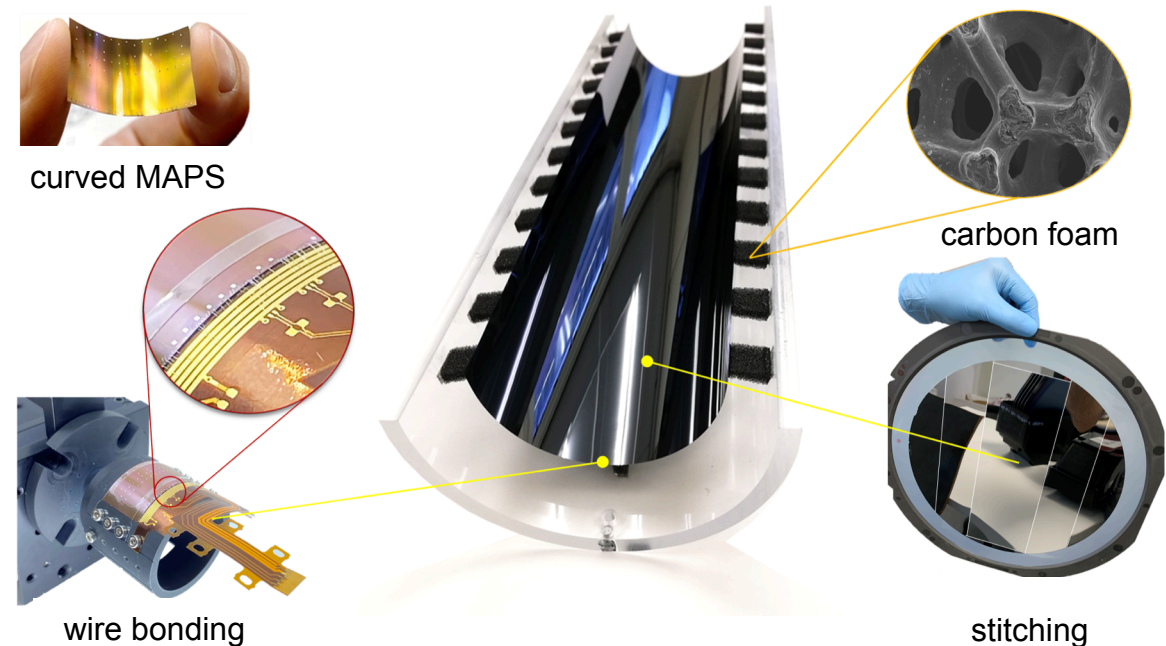
ALI-SIMUL-306864

The **systematic uncertainty** with ITS3 reduced by a factor of **2** compared to ITS2

Outlook: $p_{T,ee}$ differential measurement with ALICE 3, see the [talk by Giacomo Volpe](#)

Summary and outlook

- ITS3 — a bent wafer-scale monolithic pixel detector
- ITS3 project is on track for installation in LS3
- **A twofold improvement in spatial resolution wrt. ITS2**
 - ➔ a significant improvement in the reconstruction of heavy flavor hadrons
- **The following analysis significantly benefit from ITS3**
 - ➔ heavy flavor collectivity
 - ➔ thermal dielectron measurement
 - ➔ and many more analyses...



ITS3 TDR: [CERN-LHCC-2024-003](https://cds.cern.ch/record/2811113/files/CERN-LHCC-2024-003.pdf)

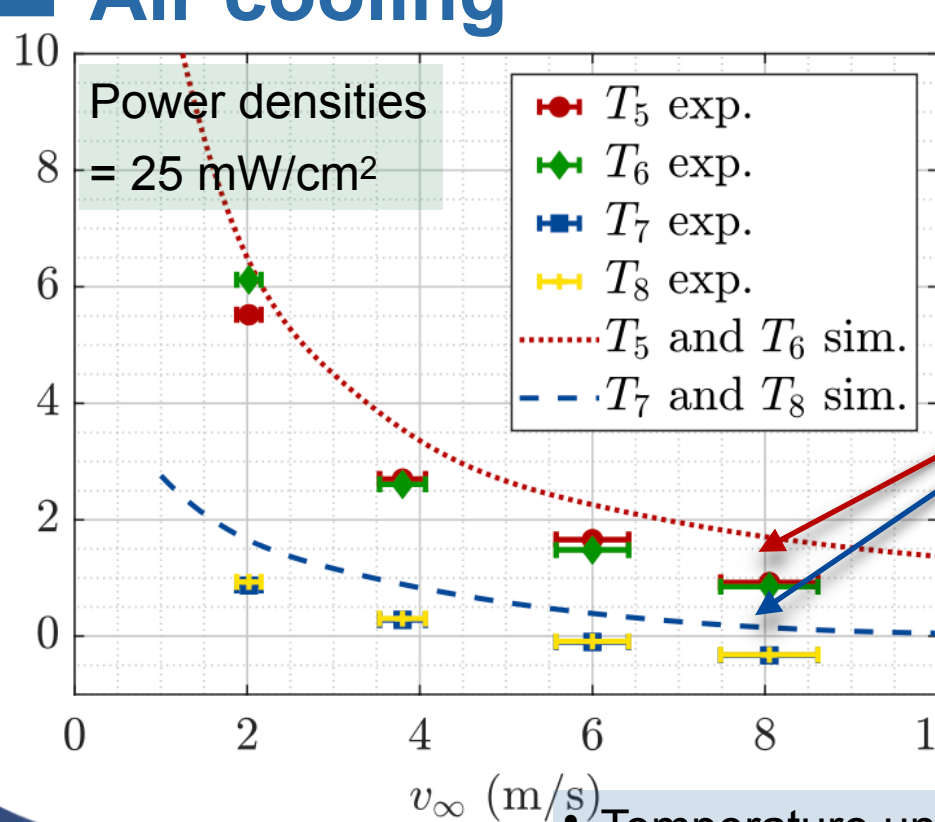
Thanks!



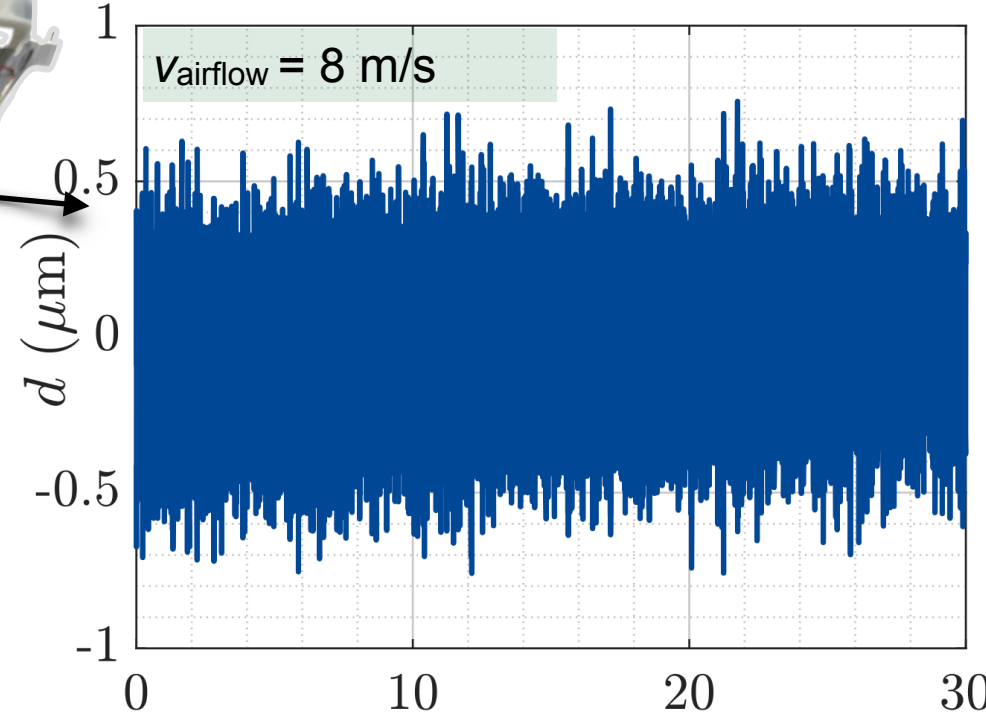
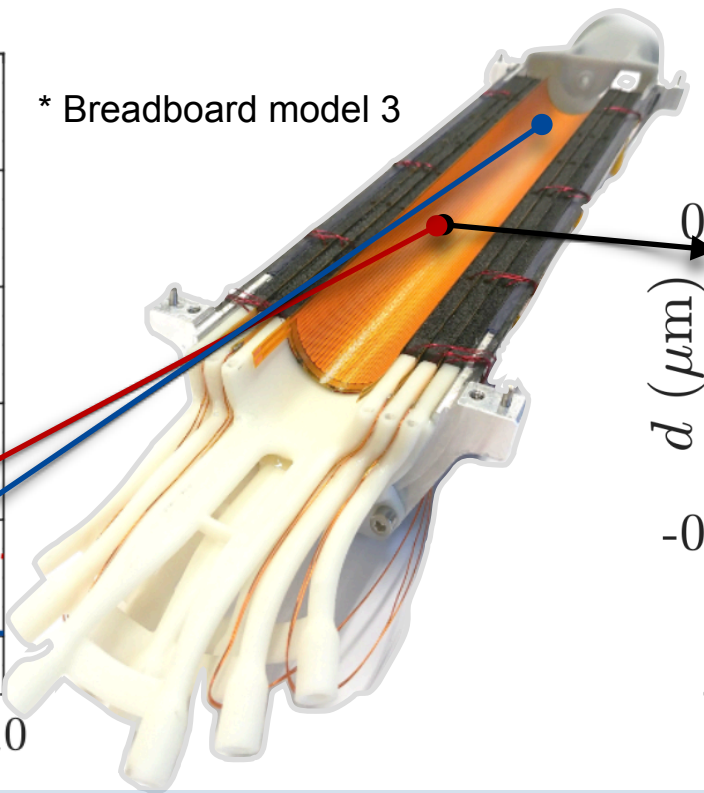
Backup



Air cooling

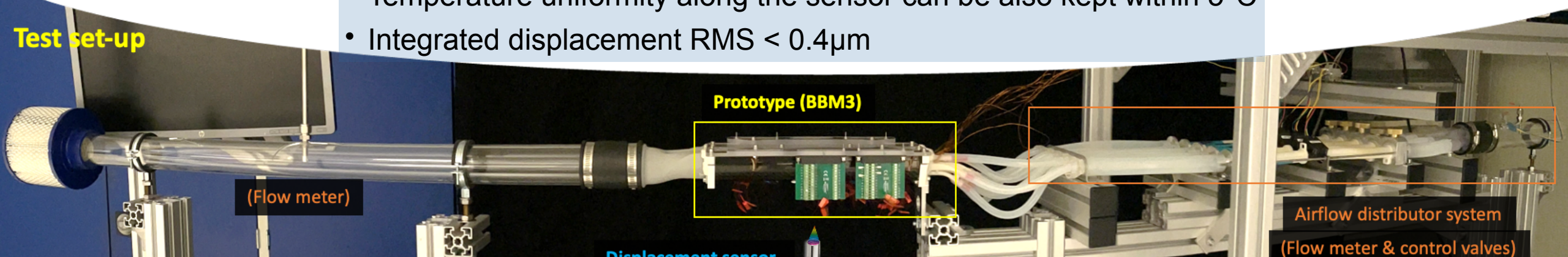


* Breadboard model 3



- Temperature uniformity along the sensor can be also kept within 5°C
- Integrated displacement RMS < 0.4 μm

Test set-up



(Flow meter)

Prototype (BBM3)

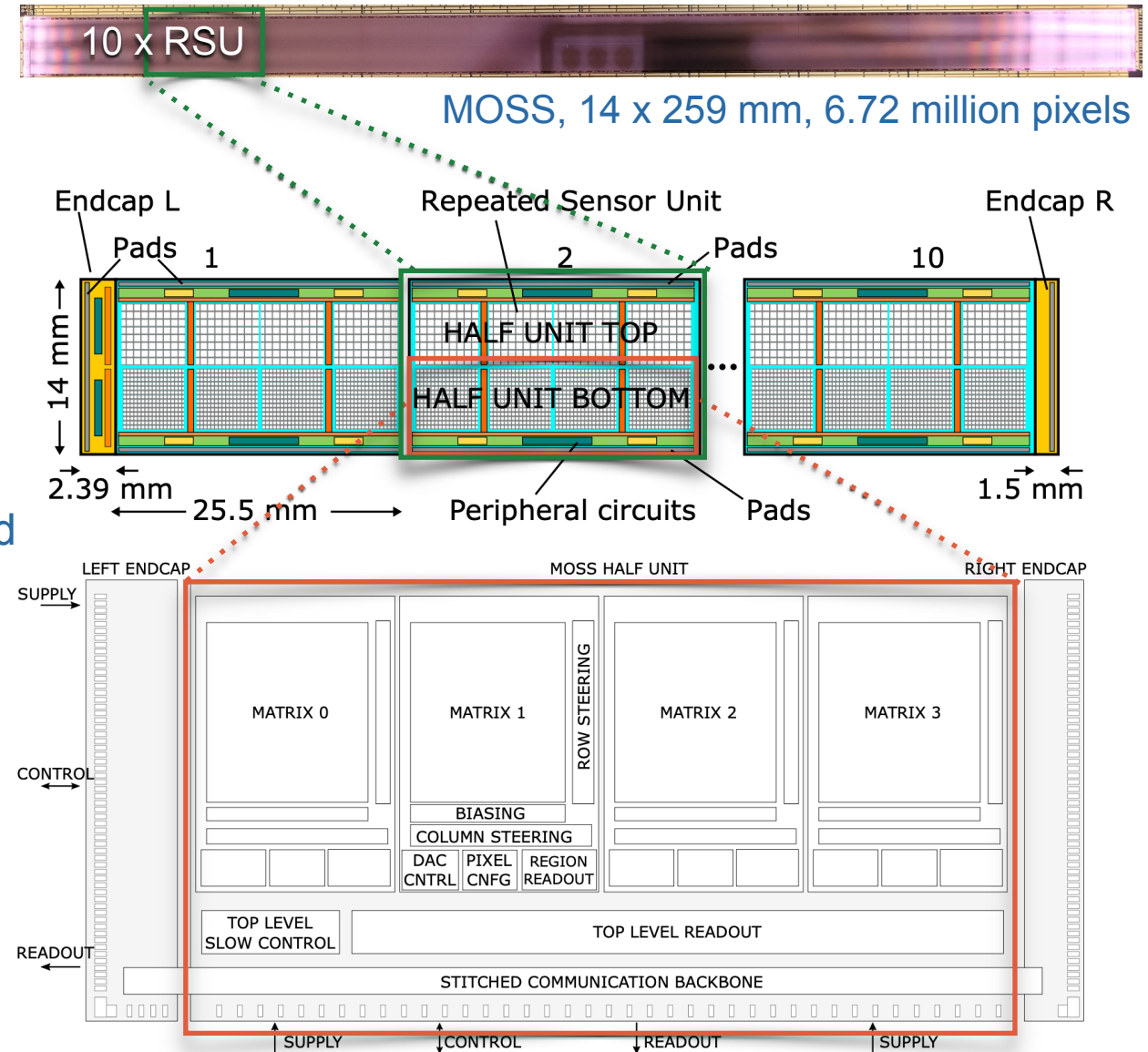
Displacement sensor (confocal chromatic)

Airflow distributor system (Flow meter & control valves)

* Image courtesy of ITS3-WP5 (Mechanics and Cooling)

MOSS details

- MOSS is segmented into 10 repeated sensor units (RSUs) and the left / right end-caps (LEC / REC)
- Each RSU split into top and bottom half units with different pitches
 - Each half unit contains 4 matrices with different distinct analog components and a top level peripheral control and readout
- Each half unit can be controlled, readout, and powered
 - by LEC (via stitched communication backbone)
 - independently, enabling separate testing to identify yield discrepancies and potential defects.



	Pixel matrix	Pixel size
Matrices on the top	256 × 256	22.5 μm
Matrices on the bottom	320 × 320	18 μm

ITS3 and sensor ASIC design parameters

Table 2.1: ITS3 general parameters.

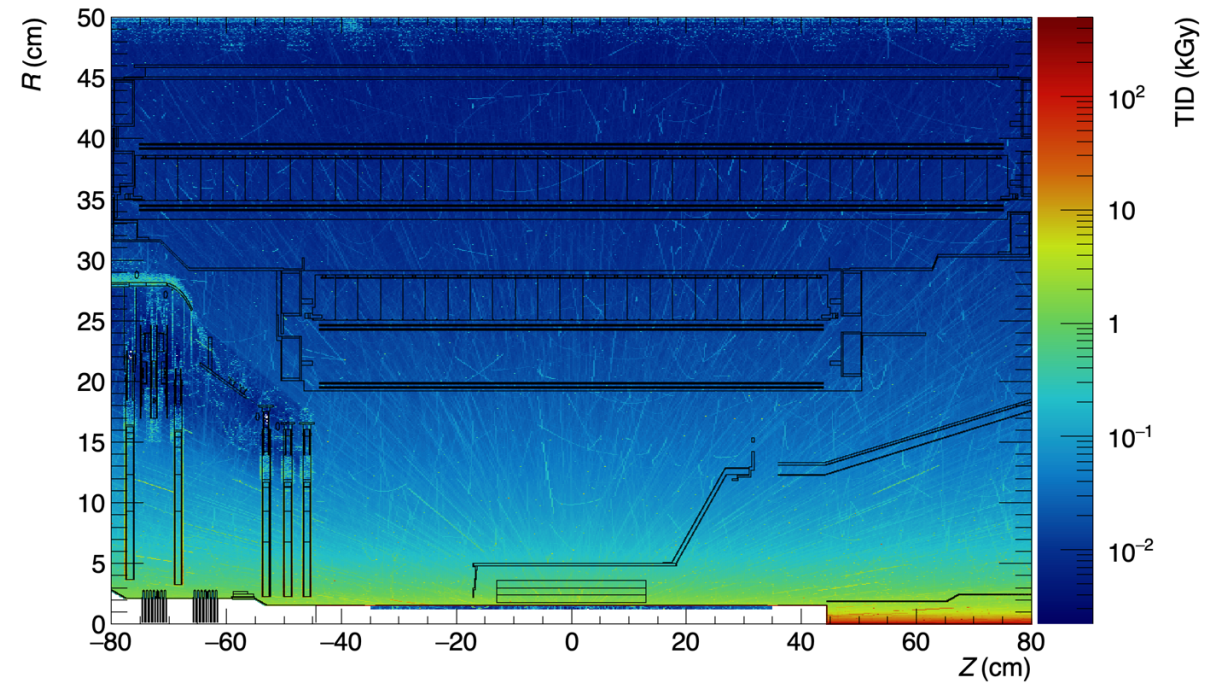
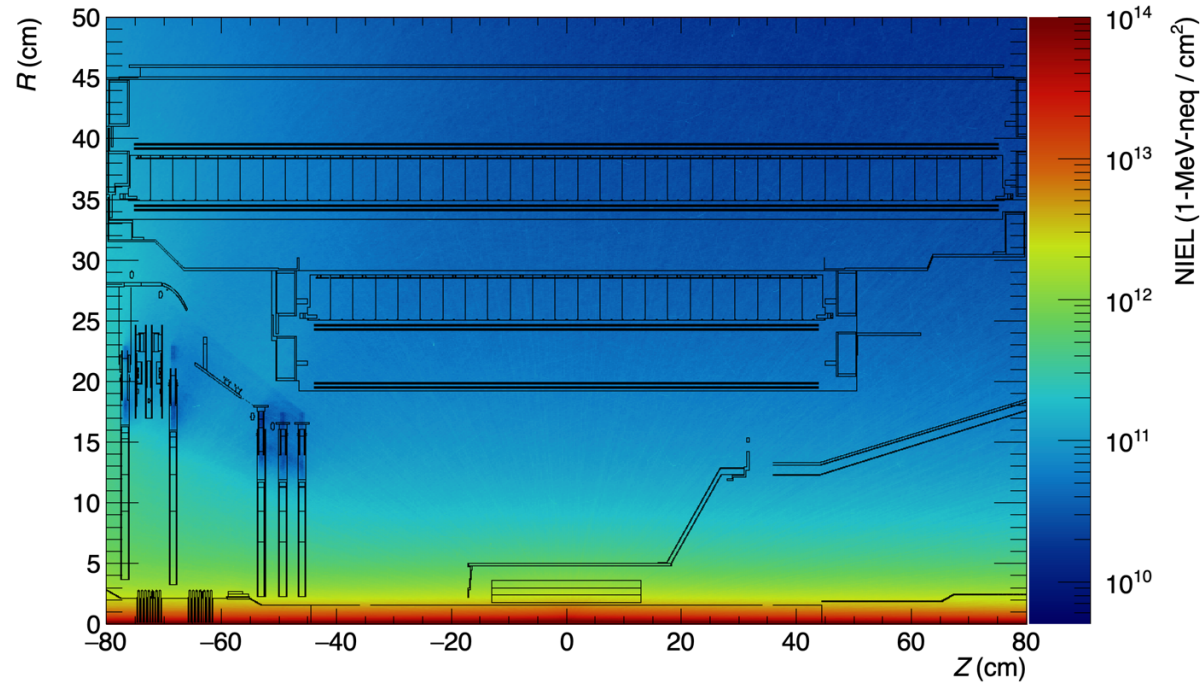
Beampipe inner/outer radius (mm)	16.0/16.5		
IB Layer parameters	Layer 0	Layer 1	Layer 2
Radial position (mm)	19.0	25.2	31.5
Length (sensitive area) (mm)	260	260	260
Pseudo-rapidity coverage ^a	± 2.5	± 2.3	± 2.0
Active area (cm ²)	305	407	507
Pixel sensors dimensions (mm ²)	266 × 58.7	266 × 78.3	266 × 97.8
Number of pixel sensors / layer	2		
Material budget (% X_0 / layer)	0.07		
Silicon thickness (μm / layer)	≤ 50		
Pixel size (μm^2)	$O(20 \times 22.5)$		
Power density (mW/cm ²)	40		
NIEL (1 MeV n_{eq} cm ⁻²)	10^{13}		
TID (kGray)	10		

^a The pseudorapidity coverage of the detector layers refers to tracks originating from a collision at the nominal interaction point ($z = 0$).

Table 3.2: General requirements for the sensor ASIC design.

Particle Rate	
Pb-Pb Interaction Rate (average)	50 kHz
Pb-Pb Interaction Rate (expected peak rate including safety factor of 2)	164 kHz
Total particle flux (@164 kHz, Layer 0, $z=0$ cm)	5.75 MHz cm^{-2}
Hadronic flux (all centralities, @164 kHz, Layer 0, $z=0$ cm)	2.55 MHz cm^{-2}
QED electrons flux (@164 kHz, Layer 0, $z=0$ cm)	3.20 MHz cm^{-2}
Detection Performance	
Single point resolution	$\lesssim 5 \mu\text{m}$
Pixel pitch	$< 25 \mu\text{m}$
Fill factor (fractional sensitive area)	$> 92\%$
Detection efficiency	$> 99\%$
Fake-hit rate	$< 0.1 \text{ pixel}^{-1} \text{ s}^{-1}$
Fake-hit occupancy (10 μs Frame Duration)	$< 10^{-6} \text{ pixel}^{-1} \text{ frame}^{-1}$
Frame duration programmable	2 – 10 μs
Readout Efficiency	
Fraction of Pb-Pb interactions fully recorded, Layer 0	$> 99.9\%$
Fraction of incomplete Pb-Pb interactions, Layer 0	$< 1 \times 10^{-3}$
Power Budget	
Power Dissipation Density, Active Region	$< 40 \text{ mW cm}^{-2}$
Power Dissipation Density, Peripheral Region	$< 1000 \text{ mW cm}^{-2}$
Radiation Load	
NIEL	$10^{13} \text{ 1 MeV } n_{\text{eq}} \text{ cm}^{-2}$
TID	10 kGy
Environmental Conditions	
Target Operating Temperature	15 °C to 30 °C

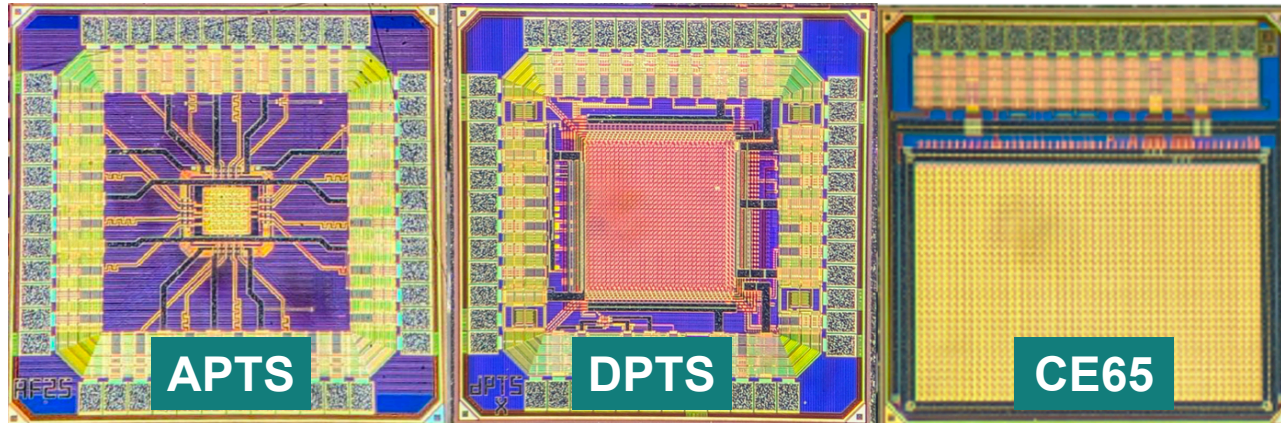
Radiation load simulation



MLR1 chips

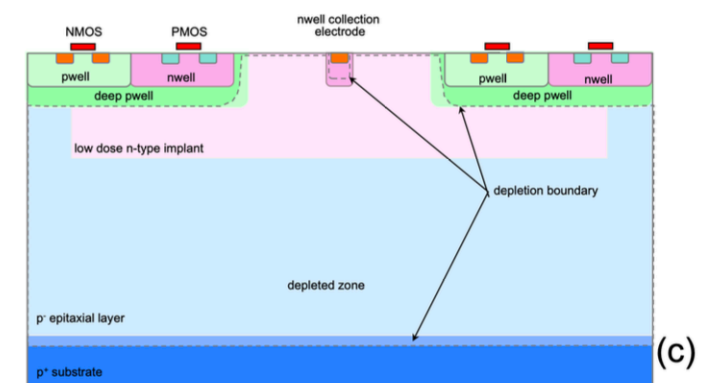
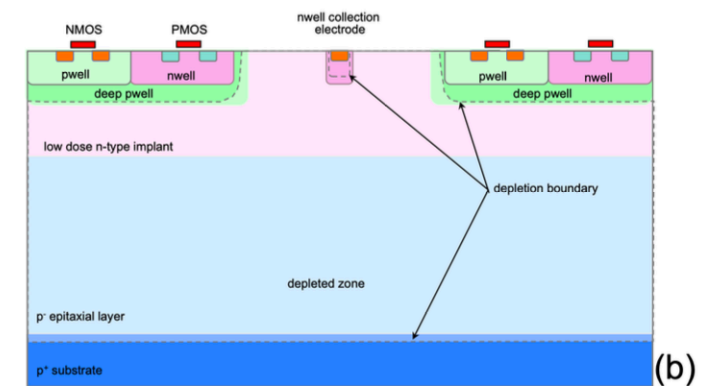
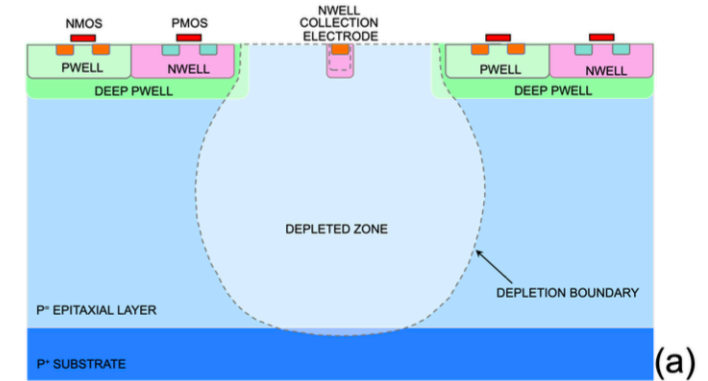


ALICE



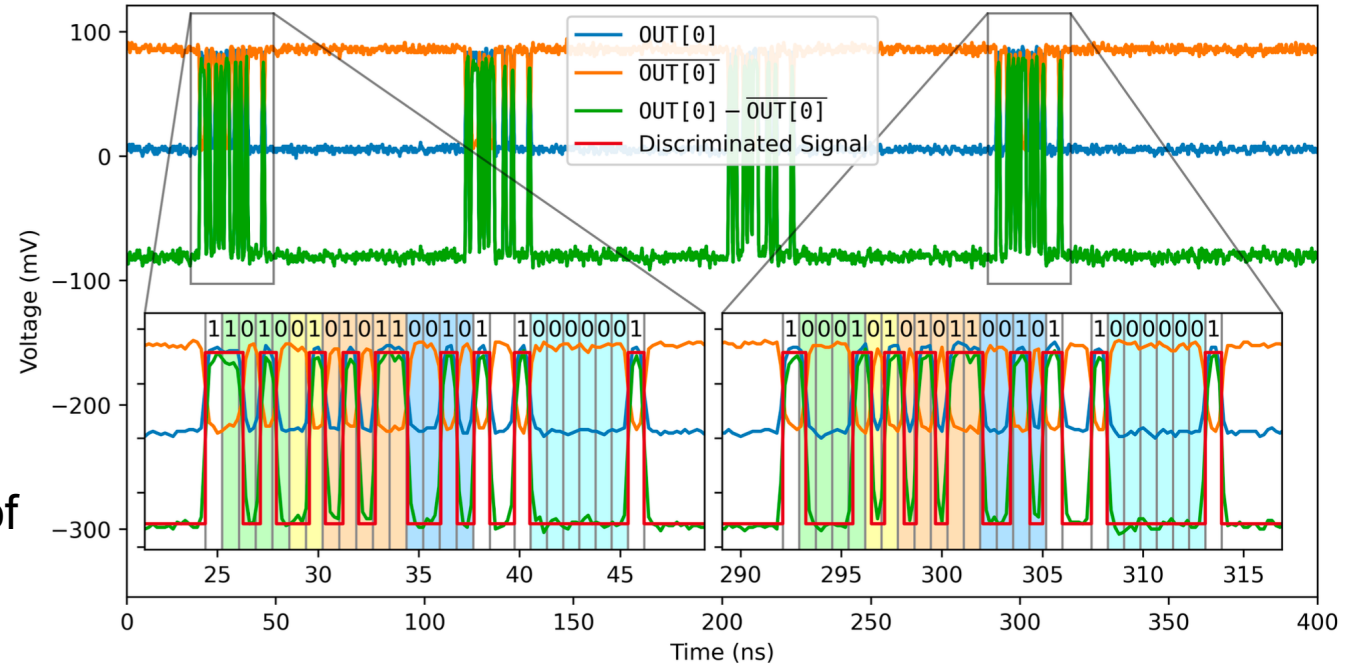
After an incredible work and effort from all the institutes involved, the **65 nm technology is validated for ITS3:**

- **APTS-SF** allowed us to establish the **most suited chip** variant in terms of performance: modified with gap, split 4, reference collection diode geometry
- **APTS-OA** enabled all the time response studies, useful beyond ITS3
- **CE65** explored different processes and pitches, confirming what observed also in other test structures
- **DPTS** was crucial for detection efficiency, spatial resolution, cluster size and radiation hardness evaluation, satisfying all the ITS3 requirements



MOST (ER1) test results

- Very densely integrated pixel matrix
 - 259 mm × 2.5 mm, 0.9 million pixels
- Power is distributed globally
 - yield is addressed by a highly granular set of switches that allow to turn off faulty parts locally
- Readout is purely asynchronous and hit-driven
 - low power consumption + timing information



Example address pulse trains from the digital pulsing of four different pixels of MOST, demonstrating a correct communication across stitching boundaries and along the chip length of 26 cm.

Detector interface with the beampipe during installation

